

DLP471NE 0.47 英寸全高清数字微镜器件

1 特性

- 0.47 英寸对角线微镜阵列
 - 1080p (1920 × 1080) 显示分辨率
 - 5.4μm 微镜间距
 - ±17° 微镜倾斜角 (相对于平坦表面)
 - 底部照明
- 高速串行接口 (HSSI) 输入数据总线
- 支持全高清 (高达 240Hz)
- 由 **DLPC7540** 显示控制器、DLPA100 电源管理和电机驱动器 IC 支持激光荧光、LED、RGB 激光和灯泡运行

2 应用

- [智能投影仪](#)
- [企业投影仪](#)

3 说明

DLP471NE 数字微镜器件 (DMD) 是一款数控微机电系统 (MEMS) 空间照明调制器 (SLM)，可用于实现高亮的全高清显示系统。TI DLP® 产品 0.47 英寸全高清 (1080p) 芯片组由 DMD、**DLPC7540** 显示控制器以及 **DLPA100** 电源和电机驱动器组成。芯片组的外形紧凑，为体型小巧的全高清显示提供完整的系统解决方案。

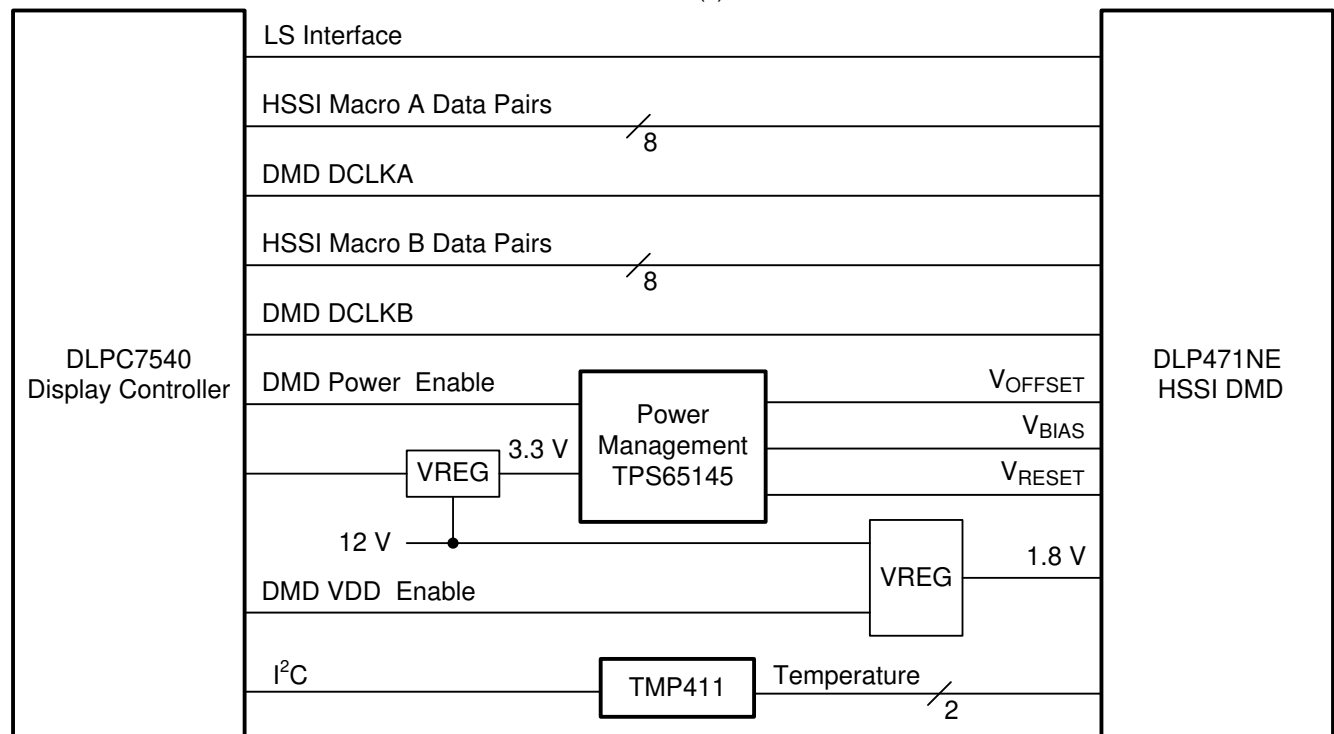
DMD 生态系统提供现成的资源以帮助用户缩短设计周期，请访问 [DLP® 产品第三方搜索工具](#)，查找获得批准的光学模块制造商和第三方提供商。

访问 [TI DLP 显示技术入门](#)，了解有关使用 DMD 开始设计的更多信息。

器件信息

器件型号 ⁽¹⁾	封装	封装尺寸
DLP471NE	FYN (149)	32.2mm × 22.3mm

(1) 如需更多信息，请参阅 [机械、封装和可订购信息](#) 附录。



简化版应用



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4 Pin Configuration and Functions

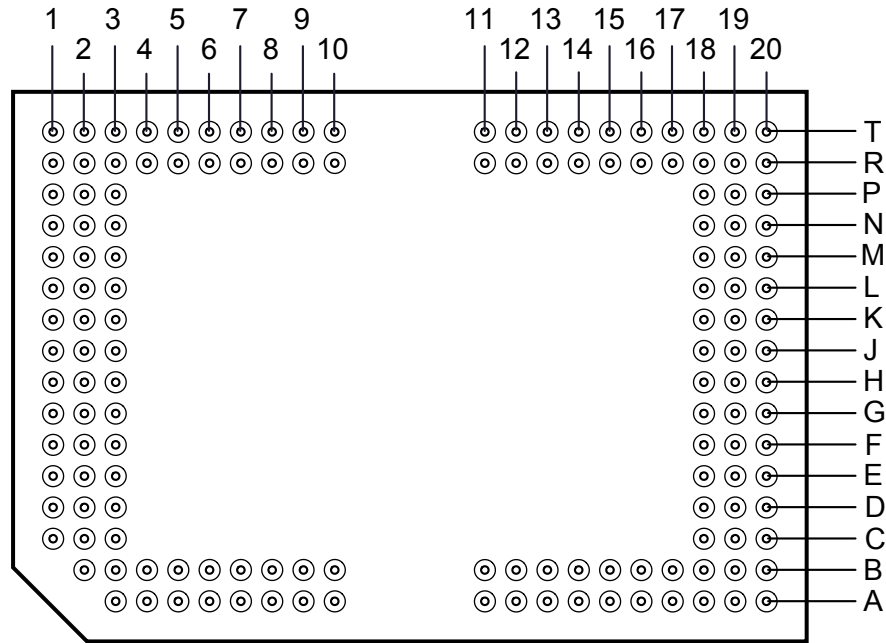


图 4-1. FYN Package 149-Pin PGA Bottom View

小心

Properly manage the layout and the operation of signals identified in the Pin Functions table to make sure there is reliable, long-term operation of the 0.47" Full HD S451 DMD. Refer to the [PCB Design Requirements for TI DLP TRP Digital Micromirror Devices](#) application report for specific details and guidelines before designing the board.

表 4-1. Pin Functions

PIN		INPUT-OUTPUT ⁽¹⁾	DESCRIPTION	TRACE LENGTH (mm)
NAME	No.			
D_AP(0)	J1	I	High-speed differential data pair lane A0	16.24427
D_AN(0)	H1	I	High-speed differential data pair lane A0	16.24426
D_AP(1)	G1	I	High-speed differential data pair lane A1	16.39699
D_AN(1)	F1	I	High-speed differential data pair lane A1	16.39691
D_AP(2)	F2	I	High-speed differential data pair lane A2	15.58905
D_AN(2)	E2	I	High-speed differential data pair lane A2	15.58908
D_AP(3)	D2	I	High-speed differential data pair lane A3	14.98471
D_AN(3)	C2	I	High-speed differential data pair lane A3	14.9844
D_AP(4)	A3	I	High-speed differential data pair lane A4	12.89101
D_AN(4)	A4	I	High-speed differential data pair lane A4	12.89101
D_AP(5)	A5	I	High-speed differential data pair lane A5	10.57206
D_AN(5)	A6	I	High-speed differential data pair lane A5	10.57242
D_AP(6)	A7	I	High-speed differential data pair lane A6	8.48593
D_AN(6)	A8	I	High-speed differential data pair lane A6	8.48702
D_AP(7)	A9	I	High-speed differential data pair lane A7	6.63434

表 4-1. Pin Functions (续)

PIN		INPUT-OUTPUT ⁽¹⁾	DESCRIPTION	TRACE LENGTH (mm)
NAME	No.			
D_AN(7)	A10	I	High-speed differential data pair lane A7	6.63441
DCLK_AP	C1	I	High-speed differential clock A	15.53899
DCLK_AN	D1	I	High-speed differential clock A	15.53868
D_BP(0)	A11	I	High-speed differential data pair lane B0	4.52398
D_BN(0)	A12	I	High-speed differential data pair lane B0	4.52368
D_BP(1)	A13	I	High-speed differential data pair lane B1	6.4103
D_BN(1)	A14	I	High-speed differential data pair lane B1	6.40894
D_BP(2)	A15	I	High-speed differential data pair lane B2	8.78102
D_BN(2)	A16	I	High-speed differential data pair lane B2	8.78364
D_BP(3)	A18	I	High-speed differential data pair lane B3	12.05827
D_BN(3)	A19	I	High-speed differential data pair lane B3	12.06154
D_BP(4)	D19	I	High-speed differential data pair lane B4	11.04817
D_BN(4)	C19	I	High-speed differential data pair lane B4	11.0479
D_BP(5)	H20	I	High-speed differential data pair lane B5	14.54976
D_BN(5)	J20	I	High-speed differential data pair lane B5	14.54991
D_BP(6)	D20	I	High-speed differential data pair lane B6	11.67363
D_BN(6)	E20	I	High-speed differential data pair lane B6	11.67598
D_BP(7)	F20	I	High-speed differential data pair lane B7	12.33442
D_BN(7)	G20	I	High-speed differential data pair lane B7	12.33409
DCLK_BP	B17	I	High-speed differential clock B	10.22973
DCLK_BN	B18	I	High-speed differential clock B	10.22551
LS_WDATA_P	T10	I	LVDS data	7.8047
LS_WDATA_N	R11	I	LVDS data	0.64391
LS_CLK_P	R9	I	LVDS CLK	8.20952
LS_CLK_N	R10	I	LVDS CLK	7.35885
LS_RDATA_A_B ISTA	T13	O	LVC MOS output	2.01174
BIST_B	T12	O	LVC MOS output	2.20006
AMUX_OUT	B20	O	Analog test mux	10.74435
DMUX_OUT	R14	O	Digital test mux	2.25459
DMD_DEN_AR STZ	T11	I	ARSTZ	2.00365
TEMP_N	R8	I	Temp diode N	9.03231
TEMP_P	R7	I	Temp diode P	11.38391
VDD	B13, B7, C18, E3, H3, J2, K3, L2, L19, M1, M2, N3, N19, P2, P18, R3, R5, R12, R17, R19, T2, T4, T6, T8, T18	P	Digital core supply voltage	Plane
VDDA	B11, B16, B4, B9, C20, D3, E18, G2, G19	P	HSSI supply voltage	Plane
VRESET	B3, R1	P	Supply voltage for negative bias of micromirror reset signal	Plane
VBIAS	E1, P1	P	Supply voltage for positive bias of micromirror reset signal	Plane

表 4-1. Pin Functions (续)

PIN		INPUT-OUTPUT ⁽¹⁾	DESCRIPTION	TRACE LENGTH (mm)
NAME	No.			
VOFFSET	A20, B2, T1, T20	P	Supply voltage for HVCMOS logic, stepped up logic level	Plane
VSS	A17, B10, B14, B6, D18, F3, F19, J3, K19, K2, L1, L3, M3, N2, N18, N20, P3, P20, R2, R4, R6, R13, R20, T5, T7, T16, T17, T19	G	Ground	Plane
VSSA	B12, B15, B19, B5, B8, C3, E19, G3, H2, H19, K1, N1, P19, R18, T3, T9	G	Ground	Plane
N/C	F18, G18, H18, J18, J19, K18, K20, L18, L20, M18, M19, M20, R15, R16, T14, T15		No connect	

(1) I=Input, O=output, P=Power, G=Ground, NC = No Connect

5 Specifications

5.1 Absolute Maximum Ratings

Operation outside the Absolute Maximum Ratings may cause permanent device damage. Absolute Maximum Ratings do not imply functional operation of the device at these or any other conditions beyond those listed under Recommended Operating Conditions. If outside the Recommended Operating Conditions but within the Absolute Maximum Ratings, the device may not be fully functional, and this may affect device reliability, functionality, performance, and shorten the device lifetime.

		MIN	MAX	UNIT
SUPPLY VOLTAGE				
V_{DD}	Supply voltage for LVCMOS core logic and LVCMOS low speed interface (LSIF) ⁽¹⁾	- 0.5	2.3	V
V_{DDA}	Supply voltage for high speed serial interface (HSSI) receivers ⁽¹⁾	- 0.3	2.2	V
V_{OFFSET}	Supply voltage for HVCMOS and micromirror electrode ^{(1) (2)}	- 0.5	11	V
V_{BIAS}	Supply voltage for micromirror electrode ⁽¹⁾	- 0.5	19	V
V_{RESET}	Supply voltage for micromirror electrode ⁽¹⁾	- 15	0.5	V
$ V_{DDA} - V_{DD} $	Supply voltage delta (absolute value) ⁽³⁾		0.3	V
$ V_{BIAS} - V_{OFFSET} $	Supply voltage delta (absolute value) ⁽⁴⁾		11	V
$ V_{BIAS} - V_{RESET} $	Supply voltage delta (absolute value) ⁽⁵⁾		34	V
INPUT VOLTAGE				
	Input voltage for other inputs - LSIF and LVCMOS ⁽¹⁾	- 0.5	2.45	V
	Input voltage for other inputs - HSSI ^{(1) (6)}	- 0.2	V_{DDA}	V
LOW SPEED INTERFACE (LSIF)				
f_{CLOCK}	LSIF clock frequency (LS_CLK)		130	MHz
$ V_{ID} $	LSIF differential input voltage magnitude ⁽⁶⁾		810	mV
I_{ID}	LSIF differential input current		10	mA
HIGH SPEED SERIAL INTERFACE (HSSI)				
f_{CLOCK}	HSSI clock frequency (DCLK)		1.65	GHz
$ V_{ID} $	HSSI differential input voltage magnitude Data Lane ⁽⁶⁾		700	mV
$ V_{ID} $	HSSI differential input voltage magnitude Clock Lane ⁽⁶⁾		700	mV
ENVIRONMENTAL				
T_{WINDOW} and T_{ARRAY}	Temperature, operating ⁽⁷⁾	0	90	°C
	Temperature, non-operating ⁽⁷⁾	- 40	90	°C
$ T_{DELTA} $	Absolute temperature delta between any point on the window edge and the ceramic test point TP1 ⁽⁸⁾		30	°C
T_{DP}	Dew point temperature, operating and non - operating (noncondensing)		81	°C

- (1) All voltage values are with respect to the ground terminals (V_{SS}). The following required power supplies must be connected for proper DMD operation: V_{DD} , V_{DDA} , V_{OFFSET} , V_{BIAS} , and V_{RESET} . All V_{SS} connections are also required.
- (2) V_{OFFSET} supply transients must fall within specified voltages.
- (3) Exceeding the recommended allowable absolute voltage difference between V_{DDA} and V_{DD} may result in excessive current draw.
- (4) Exceeding the recommended allowable absolute voltage difference between V_{BIAS} and V_{OFFSET} may result in excessive current draw.
- (5) Exceeding the recommended allowable absolute voltage difference between V_{BIAS} and V_{RESET} may result in excessive current draw.
- (6) This maximum input voltage rating applies when each input of a differential pair is at the same voltage potential. LVDS and HSSI differential inputs must not exceed the specified limit or damage may result to the internal termination resistors.
- (7) The highest temperature of the active array (as calculated using [Micromirror Array Temperature Calculation](#)) or of any point along the window edge as defined in [Figure 6-1](#). The locations of thermal test points TP2, TP3, TP4, and TP5 in [Figure 6-1](#) are intended to measure the highest window edge temperature. If a particular application causes another point on the window edge to be at a higher temperature, that point should be used.
- (8) Temperature delta is the highest difference between the ceramic test point 1 (TP1) and anywhere on the window edge as shown in [Figure 6-1](#). The window test points TP2, TP3, TP4, and TP5 shown in [Figure 6-1](#) are intended to result in the worst case delta. If a particular application causes another point on the window edge to result in a larger delta temperature, that point should be used.

5.2 Storage Conditions

Applicable for the DMD as a component or non-operating in a system.

		MIN	MAX	UNIT
T _{DMD}	DMD temperature	- 40	80	°C
T _{DP-AVG}	Average dew point temperature, non-condensing ⁽¹⁾		28	°C
T _{DP-ELR}	Elevated dew point temperature range, non-condensing ⁽²⁾	28	36	°C
CT _{ELR}	Cumulative time in elevated dew point temperature range		24	months

- (1) The average temperature over time (including storage and operating temperatures) that the device is not in the elevated dew point temperature range.
- (2) Exposure to dew point temperatures in the elevated range during storage and operation should be limited to less than a total cumulative time of CT_{ELR}.

5.3 ESD Ratings

			VALUE	UNIT
V _(ESD)	Electrostatic discharge	Human body model (HBM), per ANSI/ESDA/JEDEC JS-001 ⁽¹⁾	±2000	V
		Charged device model (CDM), per JEDEC specification JESD22-C101 ⁽²⁾	±500	V

- (1) JEDEC document JEP155 states that 500V HBM allows safe manufacturing with a standard ESD control process.
- (2) JEDEC document JEP157 states that 250V CDM allows safe manufacturing with a standard ESD control process.

5.4 Recommended Operating Conditions

Over operating free-air temperature range and supply voltages (unless otherwise noted). The functional performance of the device specified in this data sheet is achieved when operating the device within the limits defined by the Recommended Operating Conditions. No level of performance is implied when operating the device above or below the Recommended Operating Conditions limits.

		MIN	TYP	MAX	UNIT
SUPPLY VOLTAGES^{(1) (2)}					
V _{DD}	Supply voltage for LVCMOS core logic and low speed interface (LSIF)	1.71	1.8	1.95	V
V _{DDA}	Supply voltage for high speed serial interface (HSSI) receivers	1.71	1.8	1.95	V
V _{OFFSET}	Supply voltage for HVCMOS and micromirror electrode ⁽³⁾	9.5	10	10.5	V
V _{BIAS}	Supply voltage for micromirror electrode	17.5	18	18.5	V
V _{RESET}	Supply voltage for micromirror electrode	- 14.5	- 14	- 13.5	V
V _{DDA} - V _{DD}	Supply voltage delta, absolute value ⁽⁴⁾			0.3	V
V _{BIAS} - V _{OFFSET}	Supply voltage delta, absolute value ⁽⁵⁾			10.5	V
V _{BIAS} - V _{RESET}	Supply voltage delta, absolute value			33	V
LVCMOS INPUT					
V _{IH}	High level input voltage ⁽⁶⁾	0.7 × V _{DD}			V
V _{IL}	Low level input voltage ⁽⁶⁾				0.3 × V _{DD} V
LOW SPEED SERIAL INTERFACE (LSIF)					
f _{CLK}	LSIF clock frequency (LS_CLK) ⁽⁷⁾	108	120	130	MHz
DCD _{IN}	LSIF duty cycle distortion (LS_CLK)	44%		56%	
V _{ID}	LSIF differential input voltage magnitude ⁽⁷⁾	150	350	440	mV
V _{LVDS}	LSIF voltage ⁽⁷⁾	575		1520	mV
V _{CM}	Common mode voltage ⁽⁷⁾	700	900	1300	mV
Z _{LINE}	Line differential impedance (PWB/trace)	90	100	110	Ω
Z _{IN}	Internal differential termination resistance	80	100	120	Ω
HIGH SPEED SERIAL INTERFACE (HSSI)					
f _{CLK}	HSSI clock frequency (DCLK) ⁽⁸⁾	1.2		1.6	GHz

5.4 Recommended Operating Conditions (续)

Over operating free-air temperature range and supply voltages (unless otherwise noted). The functional performance of the device specified in this data sheet is achieved when operating the device within the limits defined by the Recommended Operating Conditions. No level of performance is implied when operating the device above or below the Recommended Operating Conditions limits.

		MIN	TYP	MAX	UNIT
DCD _{IN}	HSSI duty cycle distortion (DCLK)	44%	50%	56%	
V _{ID} Data	HSSI differential input voltage magnitude data lane ⁽⁸⁾	100		600	mV
V _{ID} CLK	HSSI differential input voltage magnitude Clock lane ⁽⁸⁾	295		600	mV
VCM _{DC} Data	Input common mode voltage (DC) data lane ⁽⁸⁾	200	600	800	mV
VCM _{DC} CLK	Input common mode voltage (DC) Clk lane ⁽⁸⁾	200	600	800	mV
VCM _{ACp-p}	AC peak to peak (ripple) on common mode voltage of data lane and Clock lane ⁽⁸⁾			100	mV
Z _{LINE}	Line differential impedance (PWB/trace)		100		Ω
Z _{IN}	Internal differential termination resistance (R _{Xterm})	80	100	120	Ω
ENVIRONMENTAL					
T _{ARRAY}	Array temperature, long - term operational ^{(9) (10) (12)}	10		40 to 70 ⁽¹¹⁾	°C
	Array temperature, short-term operational, 500-hour max ^{(10) (13)}	0		10	°C
T _{WINDOW}	Window temperature, operational ^{(14) (18)}			85	°C
T _{DELTA}	Absolute temperature delta between any point on the window edge and the ceramic test point TP1 ⁽¹⁵⁾			14	°C
T _{DP-AVG}	Average dew point temperature (non - condensing) ⁽¹⁶⁾			28	°C
T _{DP-ELR}	Elevated dew point temperature range (non-condensing) ⁽¹⁷⁾	28		36	°C
CT _{ELR}	Cumulative time in elevated dew point temperature range			24	months
ILL _θ	Illumination marginal ray angle ⁽¹⁸⁾			55	degrees
SOLID STATE ILLUMINATION					
ILL _{UV}	Illumination power at wavelengths < 410nm ^{(9) (20)}			10	mW/cm ²
ILL _{VIS}	Illumination power at wavelengths ≥ 410nm and ≤ 800nm ^{(19) (20)}			44.9	W/cm ²
ILL _{IR}	Illumination power at wavelengths > 800nm ⁽²⁰⁾			10	mW/cm ²
ILL _{BLU}	Illumination power at wavelengths ≥ 410nm and ≤ 475nm ^{(19) (20)}			14.3	W/cm ²
ILL _{BLU1}	Illumination power at wavelengths ≥ 410nm and ≤ 440nm ^{(19) (20)}			2.3	W/cm ²
LAMP ILLUMINATION					
ILL _{UV}	Illumination power at wavelengths < 395nm ^{(9) (20)}			2.0	mW/cm ²
ILL _{VIS}	Illumination power at wavelengths ≥ 395nm and ≤ 800nm ^{(19) (20)}			36.8	W/cm ²
ILL _{IR}	Illumination power at wavelengths > 800nm ⁽²⁰⁾			10	mW/cm ²

- (1) All power supply connections are required to operate the DMD: V_{DD}, V_{DDA}, V_{OFFSET}, V_{BIAS}, and V_{RESET}. All V_{SS} connections are required to operate the DMD.
- (2) All voltage values are with respect to the V_{SS} ground pins.
- (3) V_{OFFSET} supply transients must fall within specified max voltages.
- (4) To prevent excess current, the supply voltage delta |V_{DDA} - V_{DD}| must be less than the specified limit.
- (5) To prevent excess current, the supply voltage delta |V_{BIAS} - V_{OFFSET}| must be less than the specified limit.
- (6) LVCMOS input pin is DMD_DEN_ARSTZ.
- (7) See the low-speed interface (LSIF) timing requirements in 节 5.8.
- (8) See the high-speed serial interface (HSSI) timing requirements in 节 5.8.
- (9) Simultaneous exposure of the DMD to the maximum 节 5.4 for temperature and UV illumination reduces device lifetime.
- (10) The array temperature cannot be measured directly and must be computed analytically from the temperature measured at test point (TP1) shown in 图 6-1 and the 节 5.5 using the 节 6.6.
- (11) Per 图 5-1, the maximum operational array temperature should be derated based on the micromirror landed duty cycle that the DMD experiences in the end application. Refer to 节 6.8 for a definition of micromirror landed duty cycle.
- (12) Long-term is defined as the usable life of the device.
- (13) Short-term is the total cumulative time over the useful life of the device.

- (14) The locations of thermal test points TP2, TP3, TP4, and TP5 shown in 图 6-1 are intended to measure the highest window edge temperature. For most applications, the locations shown are representative of the highest window edge temperature. If a particular application causes additional points on the window edge to be at a higher temperature, test points should be added to those locations.
- (15) Temperature delta is the highest difference between the ceramic test point 1 (TP1) and anywhere on the window edge as shown in 图 6-1. The window test points TP2, TP3, TP4, and TP5 shown in 图 6-1 are intended to result in the worst-case delta temperature. If a particular application causes another point on the window edge to result in a larger delta in temperature, that point should be used.
- (16) The average over time (including storage and operating) that the device is not in the 'elevated dew point temperature range'.
- (17) Exposure to dew point temperatures in the elevated range during storage and operation should be limited to less than a total cumulative time of CT_{ELR} .
- (18) The maximum marginal ray angle of the incoming illumination light at any point in the micromirror array, including the pond of micromirrors (POM), should not exceed 55 degrees from the normal to the device array plane. The device window aperture has not necessarily been designed to allow incoming light at higher maximum angles to pass to the micromirrors, and the device performance has not been tested nor qualified at angles exceeding this. Illumination light exceeding this angle outside the micromirror array (including POM) will contribute to thermal limitations described in this document, and may negatively affect lifetime.
- (19) The maximum allowable optical power incident on the DMD is limited by the maximum optical power density for each wavelength range specified and the micromirror array temperature (T_{ARRAY}).
- (20) To calculate see 节 6.7.

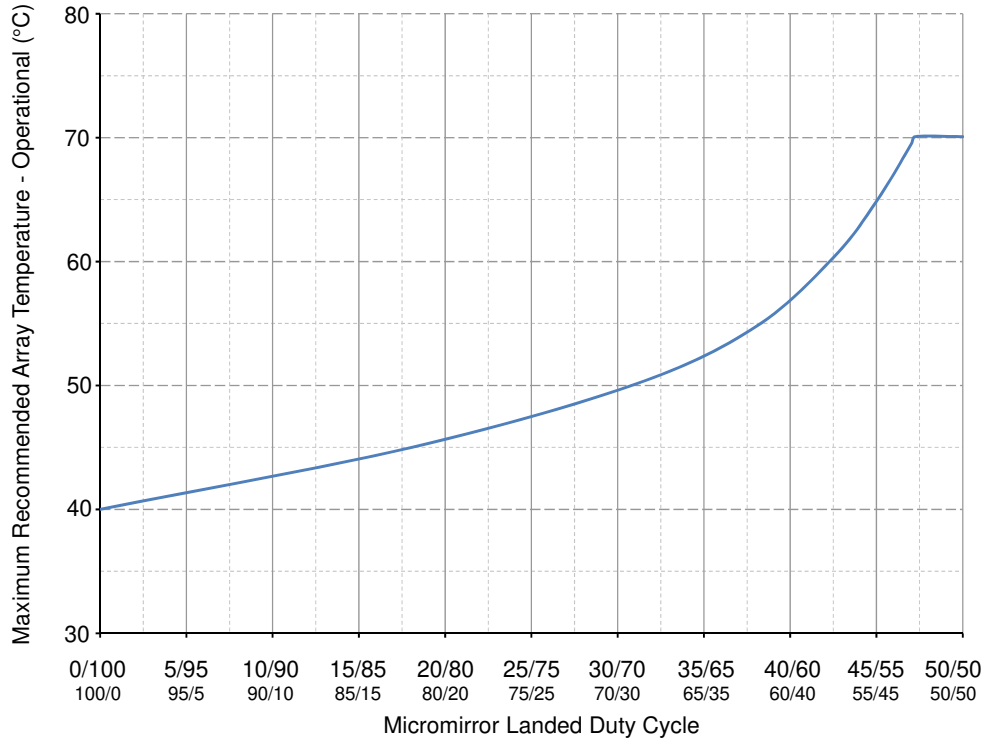


图 5-1. Maximum Recommended Array Temperature—Derating Curve

5.5 Thermal Information

THERMAL METRIC	DLP471NE	Unit
	FYP PACKAGE	
	149 PINS	
Thermal Resistance, active area to test point 1 (TP1) ⁽¹⁾	0.8	°C/W

- (1) The DMD is designed to conduct absorbed and dissipated heat to the back of the package. The cooling system must be capable of maintaining the DMD within the temperature range specified in *Recommended Operating Conditions*. The total heat load on the DMD is largely driven by the incident light absorbed by the active area; although other contributions include light energy absorbed by the window aperture and electrical power dissipation of the array. Optical systems should be designed to minimize the light energy falling outside the window's clear aperture since any additional thermal load in this area can significantly degrade the reliability of the device.

5.6 Electrical Characteristics

Over operating free-air temperature range and supply voltages (unless otherwise noted)

PARAMETER ^{(1) (2)}		TEST CONDITIONS ⁽¹⁾	MIN	TYP	MAX	UNIT
CURRENT - TYPICAL						
I _{DD}	Supply current V _{DD} ⁽³⁾			800	1200	mA
I _{DDA}	Supply current V _{DDA} ⁽³⁾			1000	1200	mA
I _{DDA}	Supply current V _{DDA} ⁽³⁾	Single macro mode		500	600	mA
I _{OFFSET}	Supply current V _{OFFSET} ^{(4) (5)}			20	25	mA
I _{BIAS}	Supply current V _{BIAS} ^{(4) (5)}			2.5	4.0	mA
I _{RESET}	Supply current V _{RESET} ⁽⁵⁾		-9.3	-6.9		mA
POWER - TYPICAL						
P _{DD}	Supply power dissipation V _{DD} ⁽³⁾			1440	2437.5	mW
P _{DDA}	Supply power dissipation V _{DDA} ⁽³⁾			1620	2340	mW
P _{DDA}	Supply power dissipation V _{DDA} ⁽³⁾	single macro mode		900	1170	mW
P _{OFFSET}	Supply power dissipation V _{OFFSET} ^{(4) (5)}			230	367.5	mW
P _{BIAS}	Supply power dissipation V _{BIAS} ^{(4) (5)}			43.2	70.3	mW
P _{RESET}	Supply power dissipation V _{RESET} ⁽⁵⁾			107.8	152.25	mW
P _{TOTAL}	Supply power dissipation Total			3441	5367.55	mW
LVC MOS INPUT						
I _{IL}	Low level input current ⁽⁶⁾	V _{DD} = 1.95 V, V _I = 0 V	-100			nA
I _{IH}	High level input current ⁽⁶⁾	V _{DD} = 1.95 V, V _I = 1.95 V			135	μA
LVC MOS OUTPUT						
V _{OH}	DC output high voltage ⁽⁷⁾	I _{OH} = -2 mA	0.8 × V _{DD}			V
V _{OL}	DC output low voltage ⁽⁷⁾	I _{OL} = 2 mA		0.2 × V _{DD}		V
RECEIVER EYE CHARACTERISTICS						
A1	Minimum data eye opening ^{(8) (9)}		100		600	mV
	Minimum clock eye opening ^{(8) (9)}		295		600	mV
A2	Maximum data signal swing ^{(8) (9)}				600	mV
X1	Maximum data eye closure ⁽⁸⁾				0.275	UI
X2	Maximum data eye closure ⁽⁸⁾				0.4	UI
t _{DRIFT}	Drift between Clock and Data between Training Patterns				20	ps
CAPACITANCE						
C _{IN}	Input capacitance LVC MOS	f = 1MHz			10	pF
C _{IN}	Input capacitance LSIF (low speed interface)	f = 1MHz			20	pF
C _{IN}	Input capacitance HSSI (high speed serial interface)	f = 1MHz			20	pF
C _{OUT}	Output capacitance	f = 1MHz			10	pF

(1) All power supply connections are required to operate the DMD: V_{DD}, V_{DDA}, V_{OFFSET}, V_{BIAS}, and V_{RESET}. All V_{SS} connections are required to operate the DMD.

(2) All voltage values are with respect to the ground pins (V_{SS}).

(3) To prevent excess current, the supply voltage delta | V_{DDA} - V_{DD} | must be less than the specified limit.

(4) To prevent excess current, the supply voltage delta | V_{BIAS} - V_{OFFSET} | must be less than the specified limit.

(5) Supply power dissipation based on three global resets in 200μs.

(6) LVC MOS input specifications are for pin DMD_DEN_ARSTZ.

(7) LVC MOS output specification is for pins LS_RDATA_A and LS_RDATA_B.

(8) Refer to [Figure 5-11](#), Receiver Eye Mask (1e-12 BER).

(9) Defined in the *Recommended Operating Conditions*.

5.7 Switching Characteristics

Over operating free-air temperature range and supply voltages (unless otherwise noted)

PARAMETER		TEST CONDITIONS	MIN	TYP	MAX	UNIT
t_{pd}	Output propagation, Clock to Q (C2Q), rising edge of LS_CLK (differential clock signal) input to LS_RDATA output. ⁽¹⁾	$C_L = 5pF$			11.1	ns
		$C_L = 10pF$			11.3	ns
	Slew rate, LS_RDATA	20% - 80%, $C_L < 10pF$	0.5			V/ns
	Output duty cycle distortion, LS_RDATA_A and LS_RDATA_B	$50 - (C2Q \text{ rise} - C2Q \text{ fall}) * 130e6 * 100$	40%		60%	

(1) See [Switching Characteristics](#).

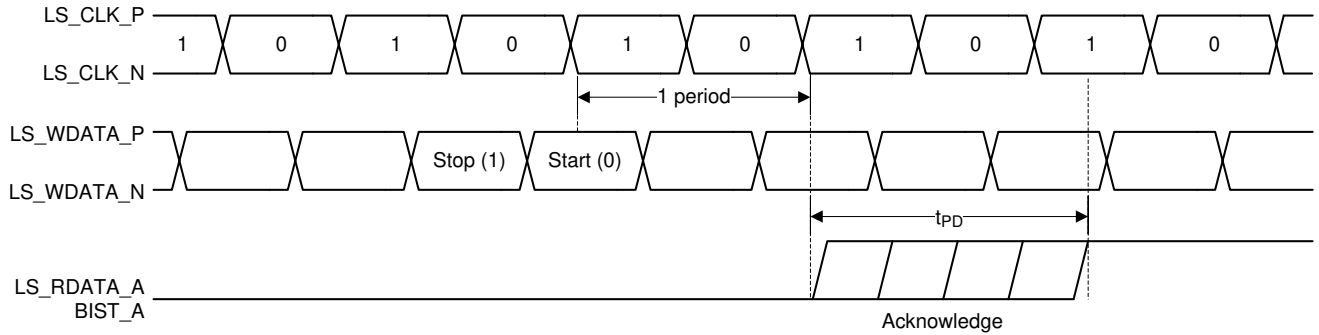


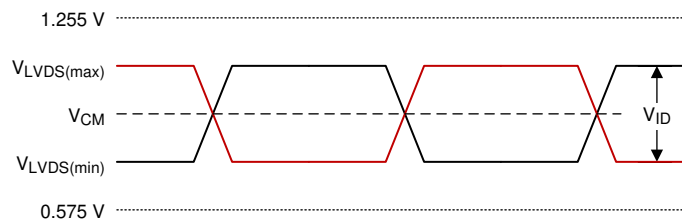
图 5-2. Switching Characteristics

5.8 Timing Requirements

Over operating free-air temperature range and supply voltages (unless otherwise noted)

PARAMETER		TEST CONDITIONS	MIN	TYP	MAX	UNIT
LVC MOS						
t_r	Rise time ⁽¹⁾	20% to 80% reference points			25	ns
t_f	Fall time ⁽¹⁾	80% to 20% reference points			25	ns
LOW SPEED INTERFACE (LSIF)						
t_r	Rise time ⁽²⁾	20% to 80% reference points			450	ps
t_f	Fall time ⁽²⁾	80% to 20% reference points			450	ps
$t_{W(H)}$	Pulse duration high ⁽³⁾	LS_CLK. 50% to 50% reference points	3.1			ns
$t_{W(L)}$	Pulse duration low ⁽³⁾	LS_CLK. 50% to 50% reference points	3.1			ns
t_{su}	Setup time ⁽⁴⁾	LS_WDATA valid before rising edge of LS_CLK (differential)			1.5	ns
t_h	Hold time ⁽⁴⁾	LS_WDATA valid after rising edge of LS_CLK (differential)			1.5	ns
HIGH SPEED SERIAL INTERFACE (HSSI)						
t_r	Rise time ⁽⁵⁾ —data	from - A1 to A1 minimum eye height specification	50		115	ps
	Rise time ⁽⁵⁾ —clock	from - A1 to A1 minimum eye height specification	50		135	ps
t_f	Fall time ⁽⁵⁾ - data	from A1 to - A1 minimum eye height specification	50		115	ps
	Fall time ⁽⁵⁾ - clock	from A1 to - A1 minimum eye height specification	50		135	ps
$t_{W(H)}$	Pulse duration high ⁽⁶⁾	DCLK. 50% to 50% reference points	0.275			ns
$t_{W(L)}$	Pulse duration low ⁽⁶⁾	DCLK. 50% to 50% reference points	0.275			ns

- (1) See [图 5-9](#) for rise time and fall time for LVC MOS.
- (2) See [图 5-5](#) for rise time and fall time for LSIF.
- (3) See [图 5-4](#) for pulse duration high and low time for LSIF.
- (4) See [图 5-4](#) for setup and hold time for LSIF.
- (5) See [图 5-10](#) for rise time and fall time for HSSI.
- (6) See [图 5-12](#) for pulse duration high and low for HSSI.



- A. See [方程式 1](#) and [方程式 2](#)

图 5-3. LSIF Waveform Requirements

$$V_{LVDS(max)} = V_{CM(max)} + \left| \frac{1}{2} \times V_{ID(max)} \right| \quad (1)$$

$$V_{LVDS(min)} = V_{CM(min)} - \left| \frac{1}{2} \times V_{ID(max)} \right| \quad (2)$$

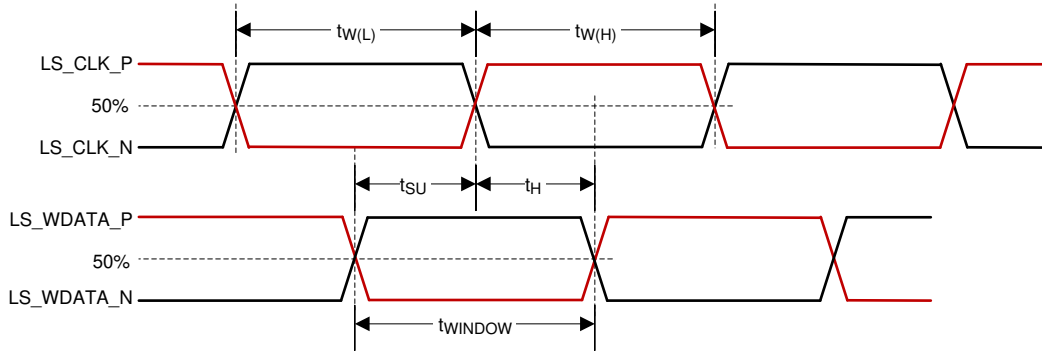


图 5-4. LSIF Timing Requirements

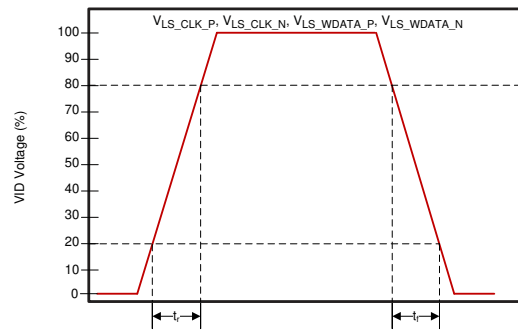


图 5-5. LSIF Rise, Fall Time Slew

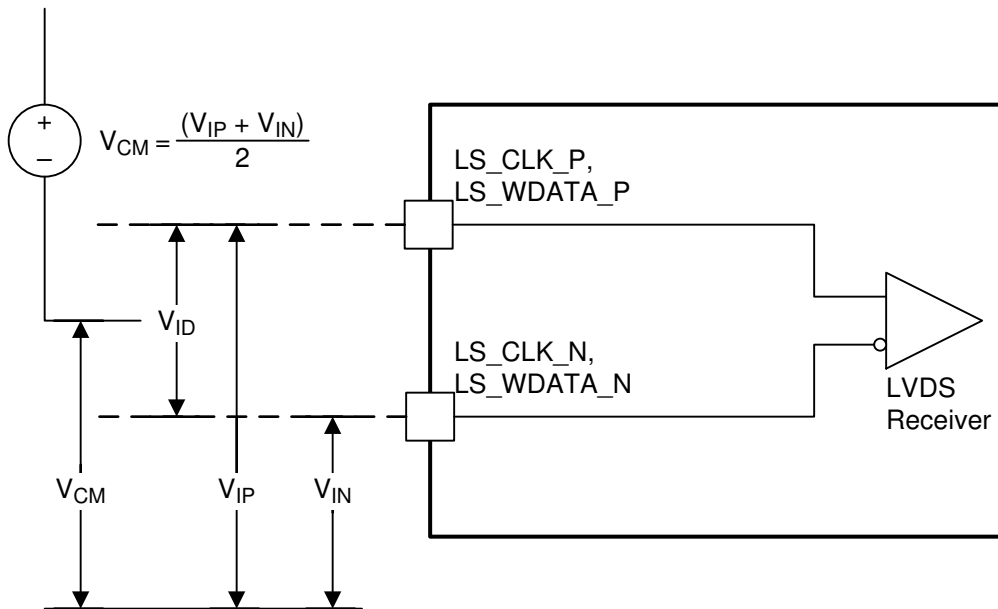


图 5-6. LSIF Voltage Requirements

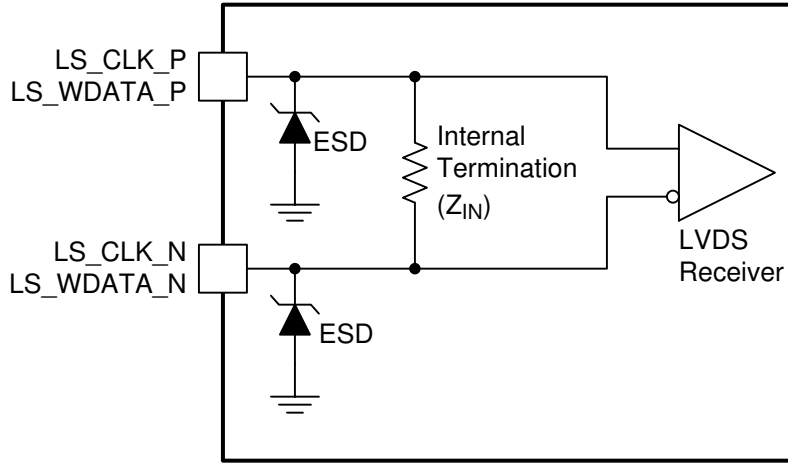


图 5-7. LSIF Equivalent Input

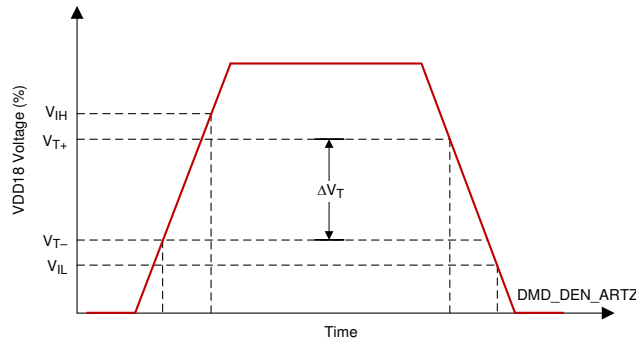


图 5-8. LVCMOS Input Hysteresis

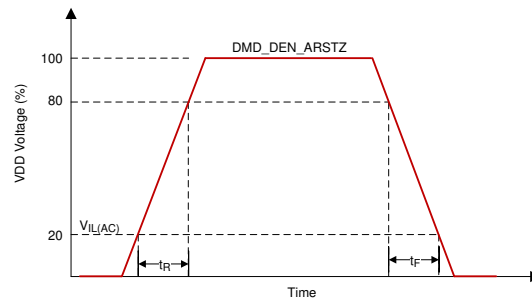
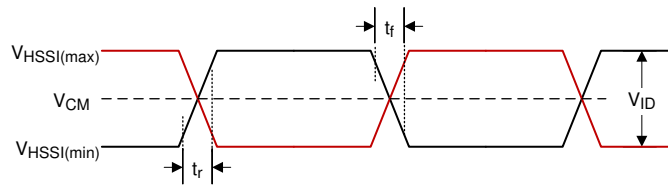


图 5-9. LVCMOS Rise, Fall Time Slew Rate



A. See 方程式 3 and 方程式 4.

图 5-10. HSSI Waveform Requirements

$$V_{\text{HSSI(max)}} = V_{\text{CM(max)}} + \left| \frac{1}{2} \times V_{\text{ID(max)}} \right| \quad (3)$$

$$V_{\text{HSSI(min)}} = V_{\text{CM(min)}} - \left| \frac{1}{2} \times V_{\text{ID(max)}} \right| \quad (4)$$

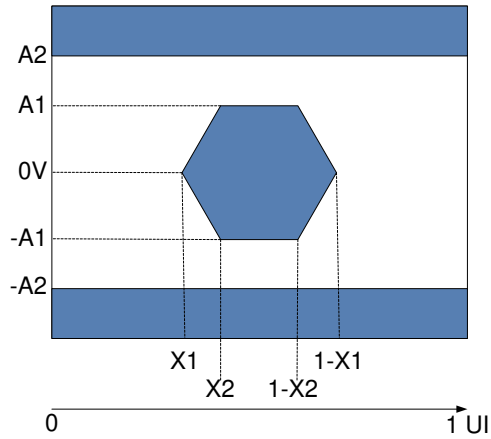


图 5-11. HSSI Eye Characteristics

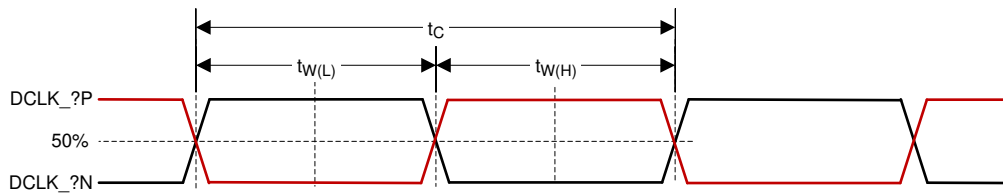


图 5-12. HSSI CLK Characteristics

5.9 System Mounting Interface Loads

PARAMETER	MIN	TYP	MAX	UNIT
When loads are applied to the electrical and thermal interface areas				
Maximum load to be applied to the electrical interface area ⁽¹⁾			111	N
Maximum load to be applied to the thermal interface area ⁽¹⁾			111	N
When a load is applied to only the electrical interface area				
Maximum load to be applied to the electrical interface area ⁽¹⁾			222	N
Maximum load to be applied to the thermal interface area ⁽¹⁾			0	N

(1) The load should be uniformly applied in the corresponding areas shown in [图 5-13](#).

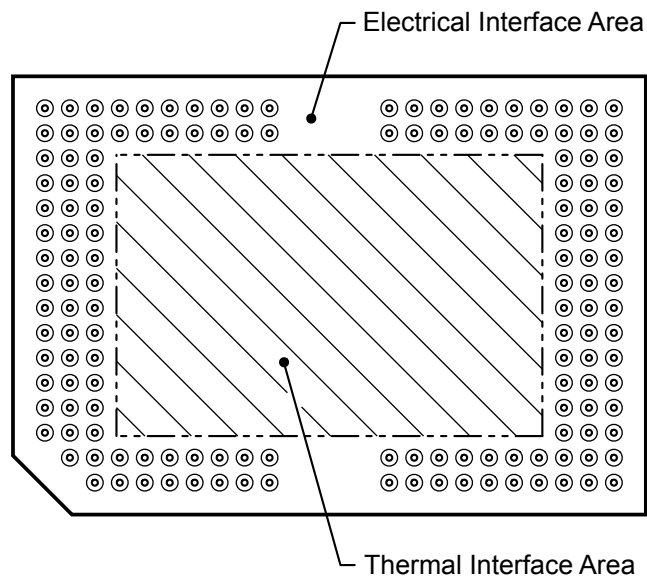


图 5-13. System Mounting Interface Loads

5.10 Micromirror Array Physical Characteristics

PARAMETER DESCRIPTION		VALUE	UNIT
Number of active columns ⁽¹⁾	M	1920	micromirrors
Number of active rows ⁽¹⁾	N	1080	micromirrors
Micromirror (pixel) pitch ⁽¹⁾	P	5.4	μ m
Micromirror active array width ⁽¹⁾	Micromirror pitch × number of active columns	10.368	mm
Micromirror active array height ⁽¹⁾	Micromirror pitch × number of active rows	5.832	mm
Micromirror active border ⁽²⁾	Pond of micromirror (POM)	20	micromirrors/side

- (1) See 图 5-14.
- (2) The structure and qualities of the border around the active array include a band of partially functional micromirrors referred to as the *Pond Of Micromirrors* (POM). These micromirrors are structurally and/or electrically prevented from tilting toward the bright or ON state but still require an electrical bias to tilt toward the OFF state.

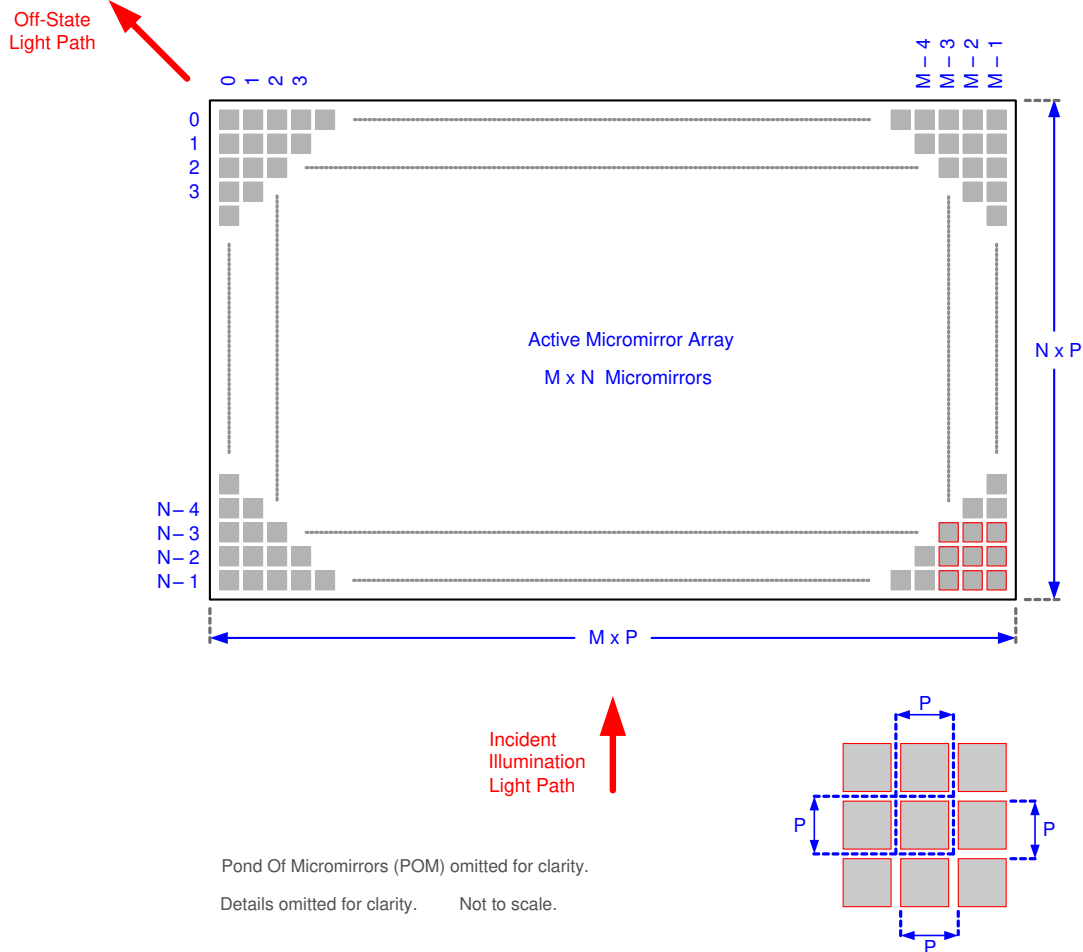
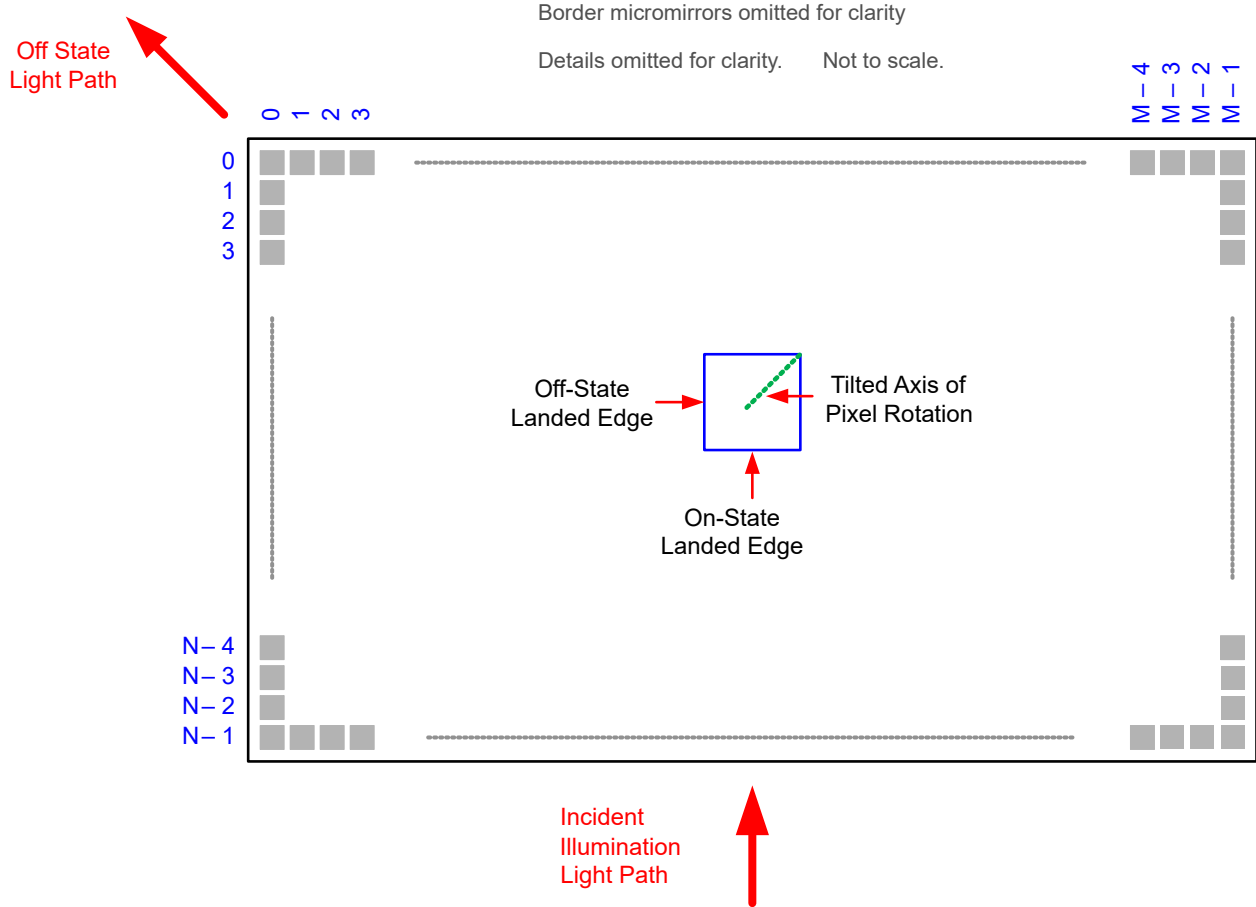


图 5-14. Micromirror Array Physical Characteristics

5.11 Micromirror Array Optical Characteristics

PARAMETER		TEST CONDITION	MIN	NOM	MAX	UNIT
Micromirror tilt angle, variation device to device ⁽²⁾ ⁽³⁾ ⁽⁴⁾ ⁽⁵⁾		Landed State ⁽¹⁾	15.6	17	18.4	degrees
Image performance ⁽⁶⁾	Bright pixel(s) in active area ⁽⁷⁾	Gray 10 screen ⁽¹⁰⁾			0	micromirrors
	Bright pixel(s) in the POM ⁽⁷⁾ ⁽⁹⁾	Gray 10 screen ⁽¹⁰⁾			1	
	Dark pixel(s) in the active area ⁽⁸⁾	White screen ⁽¹¹⁾			4	
	Adjacent pixel(s) ⁽¹²⁾	Any screen			0	
	Unstable pixel(s) in active area ⁽¹³⁾	Any screen			0	

- (1) Measured relative to the plane formed by the overall micromirror array.
- (2) Additional variation exists between the micromirror array and the package datums.
- (3) This represents the variation that can occur between any two individual micromirrors, located on the same device or located on different devices.
- (4) For some applications it is critical to account for the micromirror tilt angle variation in the overall system optical design. With some system optical designs the micromirror tilt angle variations within a device may result in perceivable non-uniformities in the light field reflected from the micromirror array. With some system optical designs the micromirror tilt angle variation between devices may result in colorimetry variations, system efficiency variations, or system contrast variations.
- (5) See figure [图 5-15](#).
- (6) Conditions of acceptance. All DMD image performance returns are evaluated using the following projected image test conditions:
- Test set degamma shall be linear.
 - Test set brightness and contrast shall be set to nominal.
 - The diagonal size of the projected image shall be a minimum of 60 inches.
 - The projections screen shall be a 1× gain.
 - The projected image shall be inspected from an 8 foot minimum viewing distance.
 - The image shall be in focus during all image performance tests.
- (7) Bright pixel definition: a single pixel or mirror that is stuck in the ON position and is visibly brighter than the surrounding pixels.
- (8) Dark pixel definition: a single pixel or mirror that is stuck in the OFF position and is visibly darker than the surrounding pixels.
- (9) POM definition: The rectangular border of off-state mirrors surrounding the active area.
- (10) Gray 10 screen definition: A full screen with RGB values set to R=10/255, G=10/255, B=10/255.
- (11) White screen definition: A full screen with RGB values set to R=255/255, G=255/255, B=255/255.
- (12) Adjacent pixel definition: Two or more stuck pixels sharing a common border or common point. Also referred to as a cluster.
- (13) Unstable pixel definition: A single pixel or mirror that does not operate in sequence with parameters loaded into memory. The unstable pixel appears to be flickering asynchronously with the image.



- A. Pond of micromirrors (POM) omitted for clarity.
- B. Refer to section # 5.10 table for M, N, and P specifications.

图 5-15. Micromirror Landed Orientation and Tilt

5.12 Window Characteristics

	DESCRIPTION ⁽¹⁾	MIN	TYP	MAX
Window material			Corning Eagle XG	
Window refractive index	At wavelength 546.1nm		1.5119	
Window transmittance, single-pass through both surfaces and glass	Minimum within the wavelength range 420nm to 680nm. Applies to all angles 0° to 30° AOI ⁽²⁾	97%		
	Average over the wavelength range 420nm to 680nm. Applies to all angles 30° to 45° AOI ⁽²⁾	97%		

(1) See [节 6.5](#) for more information.

(2) Angle of incidence (AOI) is the angle between an incident ray and the normal to a reflecting or refracting surface.

5.13 Chipset Component Usage Specification

Reliable function and operation of the DLP471NE DMD requires that it be used in conjunction with the other components of the applicable DLP chipset, including those components that contain or implement TI DMD control technology. TI DMD control technology consists of the TI technology and devices used for operating or controlling a DLP DMD.

备注

TI assumes no responsibility for image quality artifacts or DMD failures caused by optical system operating conditions exceeding the limits described previously.

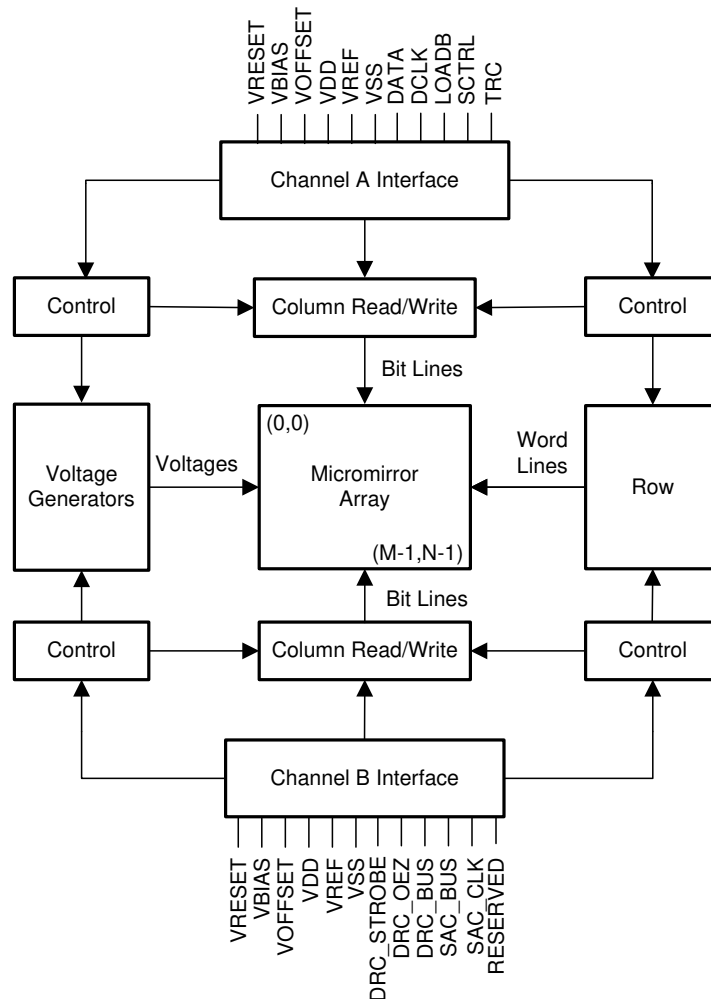
6 Detailed Description

6.1 Overview

The DMD is a 0.47-inch diagonal spatial light modulator which consists of an array of highly reflective aluminum micromirrors. The DMD is an electrical input, optical output micro-optical-electrical-mechanical system (MOEMS). The fast switching speed of the DMD micromirrors combined with advanced DLP image processing algorithms enables frame rates of up to 240Hz to be displayed. The electrical interface is low voltage differential signaling (LVDS). The DMD consists of a two-dimensional array of 1-bit CMOS memory cells. The array is organized in a grid of M memory cell columns by N memory cell rows. Refer to the [# 6.2](#). The positive or negative deflection angle of the micromirrors can be individually controlled by changing the address voltage of underlying CMOS addressing circuitry and micromirror reset signals (MBRST).

The DLP 0.47" 1080p chipset is comprised of the DLP471NE DMD, [DLPC7540](#) display controller, and the [DLPA100](#) power management and motor driver. To ensure reliable operation, the DLP471NE DMD must always be used with the DLP display controller and the power management and motor driver specified in the chipset.

6.2 Functional Block Diagram



6.3 Feature Description

6.3.1 Power Interface

The DMD requires four DC voltages: 1.8V source, V_{OFFSET} , V_{RESET} , and V_{BIAS} . In a typical configuration, 3.3V is created by the [DLPA100](#) power management and motor driver and is used on the DMD board to create the 1.8V. The TI voltage regulator [TPS65145](#) takes in the 3.3V and outputs V_{OFFSET} , V_{RESET} , V_{BIAS} .

6.3.2 Timing

The data sheet specifies the timing at the device pin. For output timing analysis, the tester pin electronics and its transmission line effects must be considered. Timing reference loads are not intended to be precise representations of any particular system environment or depiction of the actual load presented by a production test. TI recommends that system designers use IBIS or other simulation tools to correlate the timing reference load to a system environment. Use the specified load capacitance value for characterization and measurement of AC timing signals only. This load capacitance value does not indicate the maximum load the device is capable of driving.

6.4 Device Functional Modes

DMD functional modes are controlled by the [DLPC7540](#) display controller. See the [DLPC7540](#) display controller data sheet or contact a TI applications engineer.

6.5 Optical Interface and System Image Quality Considerations

TI assumes no responsibility for end-equipment optical performance. Achieving the desired end-equipment optical performance involves making trade-offs between numerous component and system design parameters. Optimizing system optical performance and image quality strongly relate to optical system design parameter trades. Although it is not possible to anticipate every conceivable application, projector image quality and optical performance is contingent on compliance with the optical system operating conditions described in the following sections.

6.5.1 Numerical Aperture and Stray Light Control

TI recommends that the light cone angle defined by the numerical aperture of the illumination optics is the same as the light cone angle defined by the numerical aperture of the projection optics. This angle must not exceed the nominal device micromirror tilt angle unless appropriate apertures are added in the illumination and/or projection pupils to block out flat-state and stray light from the projection lens. The micromirror tilt angle defines DMD capability to separate the "ON" optical path from any other light path, including undesirable flat-state specular reflections from the DMD window, DMD border structures, or other system surfaces near the DMD such as prism or lens surfaces. If the numerical aperture exceeds the micromirror tilt angle, or if the projection numerical aperture angle is more than two degrees larger than the illumination numerical aperture angle (and vice versa), contrast degradation and objectionable artifacts in the display border and/or active area could occur.

6.5.2 Pupil Match

TI's optical and image quality specifications assume that the exit pupil of the illumination optics is nominally centered within 2° of the entrance pupil of the projection optics. Misalignment of pupils can create objectionable artifacts in the display border and/or active area, which may require additional system apertures to control, especially if the numerical aperture of the system exceeds the pixel tilt angle.

6.5.3 Illumination Overfill

The active area of the device is surrounded by an aperture on the inside DMD window surface that masks structures of the DMD chip assembly from normal view, and is sized to anticipate several optical operating conditions. Overfill light illuminating the window aperture can create artifacts from the edge of the window aperture opening and other surface anomalies that may be visible on the screen. Design the illumination optical system to limit light flux incident anywhere on the window aperture from exceeding approximately 10% of the average flux level in the active area. Depending on the particular system optical architecture, overfill light may have to be further reduced below the suggested 10% level to be acceptable.

6.6 Micromirror Array Temperature Calculation

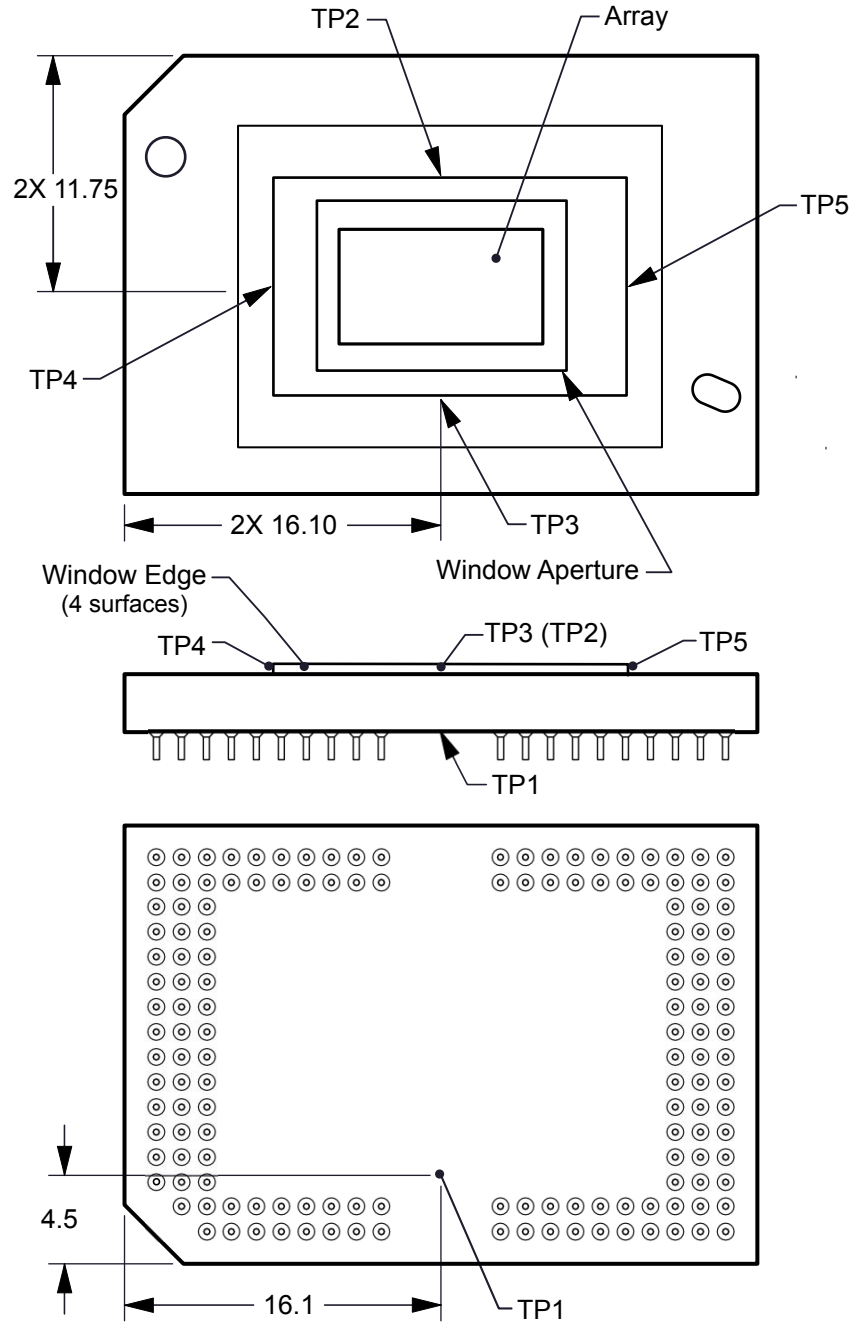


图 6-1. DMD Thermal Test Points

Micromirror array temperature cannot be measured directly, therefore it must be computed analytically from measurement points on the outside of the package, the package thermal resistance, the electrical power, and the illumination heat load. The following equations show the relationship between array temperature and the reference ceramic temperature, thermal test TP1 图 6-1 shown above:

$$T_{\text{ARRAY}} = T_{\text{CERAMIC}} + (Q_{\text{ARRAY}} \times R_{\text{ARRAY-TO-CERAMIC}})$$

$$Q_{\text{ARRAY}} = Q_{\text{ELECTRICAL}} + (Q_{\text{ILLUMINATION}})$$

where

- T_{ARRAY} = Computed array temperature ($^{\circ}\text{C}$)
- T_{CERAMIC} = Measured ceramic temperature ($^{\circ}\text{C}$), TP1 图 6-1
- $R_{\text{ARRAY-TO-CERAMIC}}$ = Thermal resistance of package specified in 节 5.5 from array to ceramic TP1 图 6-1 ($^{\circ}\text{C}/\text{W}$).
- Q_{ARRAY} = Total DMD Power (electrical + absorbed) on array (W).
- $Q_{\text{ELECTRICAL}}$ = Nominal electrical power (W)
- Q_{INCIDENT} = Incident illumination optical power (W)
- $Q_{\text{ILLUMINATION}}$ = (DMD average thermal absorptivity \times Q_{INCIDENT}) (W)
- DMD average thermal absorptivity = 0.41

The electrical power dissipation of the DMD is variable and depends on the voltages, data rates, and operating frequencies. A nominal electrical power dissipation to use when calculating array temperature is 2.5W. The absorbed optical power from the illumination source is variable and depends on the operating state of the micromirrors and the intensity of the light source. The equations shown above are valid for a single chip or multichip DMD system. It assumes an illumination distribution of 83.7% on the active array and 16.3% on the array border.

The sample calculation for a typical projection application is as follows:

$$Q_{\text{INCIDENT}} = 31\text{W (measured)}$$

$$T_{\text{CERAMIC}} = 55.0^{\circ} \text{ (measured)}$$

$$Q_{\text{ELECTRICAL}} = 2.5\text{W}$$

$$Q_{\text{ARRAY}} = 2.5\text{W} + (0.41 \times 31\text{W}) = 15.21\text{W}$$

$$T_{\text{ARRAY}} = 55.0^{\circ}\text{C} + (15.21\text{W} \times 0.80^{\circ}\text{C}/\text{W}) = 67.2^{\circ}\text{C}$$

6.7 Micromirror Power Density Calculation

The calculation of the optical power density of the illumination on the DMD in the different wavelength bands uses the total measured optical power on the DMD, percent illumination overfill, area of the active array, and the ratio of the spectrum in the wavelength band of interest to the total spectral optical power.

- $ILL_{\text{UV}} = [OP_{\text{UV-RATIO}} \times Q_{\text{INCIDENT}}] \times 1000\text{mW}/\text{W} \div A_{\text{ILL}}$ (mW/cm^2)
- $ILL_{\text{VIS}} = [OP_{\text{VIS-RATIO}} \times Q_{\text{INCIDENT}}] \div A_{\text{ILL}}$ (W/cm^2)
- $ILL_{\text{IR}} = [OP_{\text{IR-RATIO}} \times Q_{\text{INCIDENT}}] \times 1000\text{mW}/\text{W} \div A_{\text{ILL}}$ (mW/cm^2)
- $ILL_{\text{BLU}} = [OP_{\text{BLU-RATIO}} \times Q_{\text{INCIDENT}}] \div A_{\text{ILL}}$ (W/cm^2)
- $ILL_{\text{BLU1}} = [OP_{\text{BLU1-RATIO}} \times Q_{\text{INCIDENT}}] \div A_{\text{ILL}}$ (W/cm^2)
- $A_{\text{ILL}} = A_{\text{ARRAY}} \div (1 - OV_{\text{ILL}})$ (cm^2)

where:

- ILL_{UV} = UV illumination power density on the DMD (mW/cm^2)
- ILL_{VIS} = VIS illumination power density on the DMD (W/cm^2)
- ILL_{IR} = IR illumination power density on the DMD (mW/cm^2)

- ILL_{BLU} = BLU illumination power density on the DMD (W/cm²)
- ILL_{BLU1} = BLU1 illumination power density on the DMD (W/cm²)
- A_{ILL} = illumination area on the DMD (cm²)
- $Q_{INCIDENT}$ = total incident optical power on DMD (W) (measured)
- A_{ARRAY} = area of the array (cm²) (data sheet)
- OV_{ILL} = percent of total illumination on the DMD outside the array (%) (optical model)
- $OP_{UV-RATIO}$ = ratio of the optical power for wavelengths <410nm to the total optical power in the illumination spectrum (spectral measurement)
- $OP_{VIS-RATIO}$ = ratio of the optical power for wavelengths ≥ 410 nm and ≤ 800 nm to the total optical power in the illumination spectrum (spectral measurement)
- $OP_{IR-RATIO}$ = ratio of the optical power for wavelengths >800nm to the total optical power in the illumination spectrum (spectral measurement)
- $OP_{BLU-RATIO}$ = ratio of the optical power for wavelengths ≥ 410 nm and ≤ 475 nm to the total optical power in the illumination spectrum (spectral measurement)
- $OP_{BLU1-RATIO}$ = ratio of the optical power for wavelengths ≥ 410 nm and ≤ 440 nm to the total optical power in the illumination spectrum (spectral measurement)

The illumination area varies and depends on the illumination overfill. The total illumination area on the DMD is the array area and the overfill area around the array. The optical model is used to determine the percent of the total illumination on the DMD that is outside the array (OV_{ILL}) and the percent of the total illumination that is on the active array. From these values, the illumination area (A_{ILL}) is calculated. The illumination is assumed to be uniform across the entire array.

From the measured illumination spectrum, the ratio of the optical power in the wavelength bands of interest to the total optical power is calculated.

Sample calculation:

$$Q_{INCIDENT} = 31W \text{ (measured)}$$

$$A_{ARRAY} = (10.3680mm \times 5.8320mm) \div 100mm^2/cm^2 = 0.6047cm^2 \text{ (data sheet)}$$

$$OV_{ILL} = 16.3\% \text{ (optical model)}$$

$$OP_{UV-RATIO} = 0.00017 \text{ (spectral measurement)}$$

$$OP_{VIS-RATIO} = 0.99977 \text{ (spectral measurement)}$$

$$OP_{IR-RATIO} = 0.00006 \text{ (spectral measurement)}$$

$$OP_{BLU-RATIO} = 0.28100 \text{ (spectral measurement)}$$

$$OP_{BLU1-RATIO} = 0.03200 \text{ (spectral measurement)}$$

$$A_{ILL} = 0.6047cm^2 \div (1 - 0.163) = 0.7224cm^2$$

$$ILL_{UV} = [0.00017 \times 31W] \times 1000mW/W \div 0.7224cm^2 = 7.295mW/cm^2$$

$$ILL_{VIS} = [0.99977 \times 31W] \div 0.7224cm^2 = 42.90W/cm^2$$

$$ILL_{IR} = [0.00006 \times 31W] \times 1000mW/W \div 0.7224cm^2 = 2.575mW/cm^2$$

$$ILL_{BLU} = [0.28100 \times 31W] \div 0.7224cm^2 = 12.06W/cm^2$$

$$ILL_{BLU1} = [0.03200 \times 31W] \div 0.7224cm^2 = 1.37W/cm^2$$

6.8 Micromirror Landed-On/Landed-Off Duty Cycle

6.8.1 Definition of Micromirror Landed-On/Landed-Off Duty Cycle

The micromirror landed-on/landed-off duty cycle (landed duty cycle) denotes the percentage of time that an individual micromirror is landed in the ON state versus the amount of time the same micromirror is landed in the OFF state.

For example, a landed duty cycle of 100/0 indicates that the referenced pixel is in the ON state 100% of the time (and in the OFF state 0% of the time); whereas 0/100 would indicate that the pixel is in the OFF state 100% of the time. Likewise, 50/50 indicates that the pixel is ON for 50% of the time (and OFF for 50% of the time).

Note that when assessing the landed duty cycle, the time spent switching from one state (ON or OFF) to the other state (OFF or ON) is considered negligible and is thus ignored.

Since a micromirror can only be landed in one state or the other (ON or OFF), the two numbers (percentages) always add to 100.

6.8.2 Landed Duty Cycle and Useful Life of the DMD

Knowing the long-term average landed duty cycle (of the end product or application) is important because subjecting all (or a portion) of the DMD micromirror array (also called the active array) to an asymmetric landed duty cycle for a prolonged period of time can reduce the DMD useful life.

Note that it is the symmetry/asymmetry of the landed duty cycle that is of relevance. The symmetry of the landed duty cycle is determined by how close the two numbers (percentages) are to being equal. For example, a landed duty cycle of 50/50 is perfectly symmetrical whereas a landed duty cycle of 100/0 or 0/100 is perfectly asymmetrical.

6.8.3 Landed Duty Cycle and Operational DMD Temperature

Operational DMD temperature and landed duty cycle interact to affect DMD useful life, and this interaction can be exploited to reduce the impact that an asymmetrical landed duty cycle has on the DMD useful life. This is quantified in the derating curve shown in the *Recommended Operating Conditions*. The importance of this curve is that:

- All points along this curve represent the same useful life.
- All points above this curve represent lower useful life (and the further away from the curve, the lower the useful life).
- All points below this curve represent higher useful life (and the further away from the curve, the higher the useful life).

In practice, this curve specifies the maximum operating DMD temperature for a given long-term average landed duty cycle.

6.8.4 Estimating the Long-Term Average Landed Duty Cycle of a Product or Application

During a given period of time, the landed duty cycle of a given pixel follows from the image content being displayed by that pixel.

For example, in the simplest case, when displaying pure-white on a given pixel for a given time period, that pixel operates under a 100/0 landed duty cycle during that time period. Likewise, when displaying pure-black, the pixel operates under a 0/100 landed duty cycle.

Between the two extremes (ignoring for the moment color and any image processing that may be applied to an incoming image), the landed duty cycle tracks one-to-one with the gray scale value, as shown in [表 6-1](#).

表 6-1. Grayscale Value and Landed Duty Cycle

GRAYSCALE VALUE	LANDED DUTY CYCLE
0%	0/100
10%	10/90
20%	20/80
30%	30/70
40%	40/60
50%	50/50
60%	60/40
70%	70/30
80%	80/20
90%	90/10
100%	100/0

Accounting for color rendition (but still ignoring image processing) requires knowing both the color intensity (from 0% to 100%) for each constituent primary color (red, green, and/or blue) for the given pixel as well as the color cycle time for each primary color, where “color cycle time” is the total percentage of the frame time that a given primary must be displayed to achieve the desired white point.

Use this equation to calculate the landed duty cycle of a given pixel during a given time period:

Landed Duty Cycle =

(Red_Cycle_% × Red_Scale_Value) +

(Green_Cycle_% × Green_Scale_Value) +

(Blue_Cycle_% × Blue_Scale_Value)

where

- Red_Cycle_%, represents the percentage of the frame time that red is displayed to achieve the desired white point
- Green_Cycle_% represents the percentage of the frame time that green is displayed to achieve the desired white point
- Blue_Cycle_%, represents the percentage of the frame time that blue is displayed to achieve the desired white point

For example, assume that the red, green, and blue color cycle times are 30%, 50%, and 20% respectively (to achieve the desired white point), then the landed duty cycle for various combinations of red, green, blue color intensities would be as shown in [表 6-2](#) and [表 6-3](#).

表 6-2. Example Landed Duty Cycle for Full-Color, Color Percentage

CYCLE PERCENTAGE		
RED	GREEN	BLUE
30%	50%	20%

表 6-3. Example Landed Duty Cycle for Full-Color

SCALE VALUE			LANDED DUTY CYCLE
RED	GREEN	BLUE	
0%	0%	0%	0/100
100%	0%	0%	30/70
0%	100%	0%	50/50
0%	0%	100%	20/80
0%	12%	0%	6/94
0%	0%	35%	7/93
60%	0%	0%	18/82
0%	100%	100%	70/30
100%	0%	100%	50/50
100%	100%	0%	80/20
0%	12%	35%	13/87
60%	0%	35%	25/75
60%	12%	0%	24/76
100%	100%	100%	100/0

The last factor to account for in estimating the landed duty cycle is any applied image processing. Within the DLPC7540 controller, the gamma function affects the landed duty cycle.

Gamma is a power function of the form $Output_Level = A \times Input_Level^{Gamma}$, where A is a scaling factor that is typically set to 1.

In the DLPC7540 controller, gamma is applied to the incoming image data on a pixel-by-pixel basis. A typical gamma factor is 2.2, which transforms the incoming data as shown in 图 6-2.

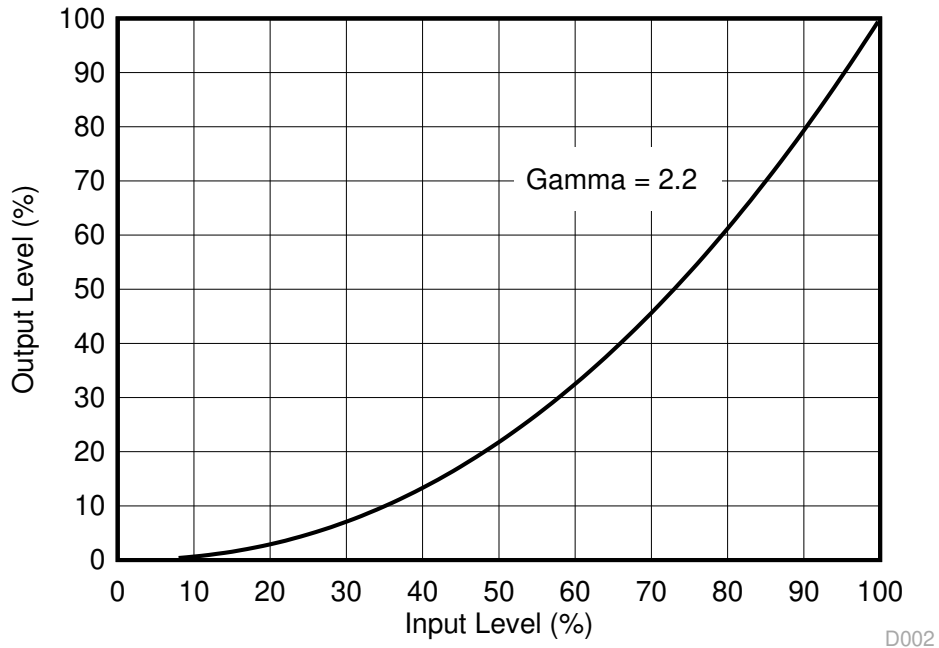


图 6-2. Example of Gamma = 2.2

From 图 6-2, if the gray scale value of a given input pixel is 40% (before gamma is applied), then gray scale value is 13% after gamma is applied. Therefore, it can be seen that since gamma has a direct impact on the displayed gray scale level of a pixel, it also has a direct impact on the landed duty cycle of a pixel.

Consideration must also be given to any image processing which occurs before the [DLPC7540](#) controllers.

7 Application and Implementation

备注

以下应用部分中的信息不属于 TI 器件规格的范围，TI 不担保其准确性和完整性。TI 的客户应负责确定器件是否适用于其应用。客户应验证并测试其设计，以确保系统功能。

7.1 Application Information

DMDs are spatial light modulators that reflect incoming light from an illumination source to one of two directions, with the primary direction being into a projection or collection optic. Each application is derived primarily from the optical architecture of the system and the format of the data coming into the [DLPC7540](#) controller. The high tilt pixel in the bottom-illuminated DMD increases brightness performance and enables a smaller system footprint for thickness-constrained applications. Typical applications using the DLP471NE include smart projectors and enterprise projectors.

DMD power-up and power-down sequencing are strictly controlled by the [DLPC7540](#) through the TPS65145 PMIC. Refer to [节 8](#) for power-up and power-down specifications. To ensure reliable operation, the DLP471NE DMD must always be used with a [DLPC7540](#) controller, a [DLPA100](#) PMIC/motor driver, and a [TPS65145](#) PMIC.

7.2 Typical Application

The DLP471NE DMD combined with [DLPC7540](#) digital controller and a power management device provides full HD (1920x1080) resolution for bright, colorful display applications. A typical display system using laser phosphor illumination combines the DLP471NE DMD, [DLPC7540](#) display controller, [TPS65145](#) voltage regulator and [DLPA100](#) PMIC and motor driver. [图 7-1](#) shows a system block diagram for this configuration of the DLP 0.47” Full HD chipset and additional system components needed. See [图 7-2](#), a block diagram showing the system components needed along with the lamp configuration of the DLP 0.47” Full HD chipset. The components include the DLP471NE DMD, [DLPC7540](#) display controller and the [DLPA100](#) PMIC and motor driver and a [TPS65145](#) PMIC.

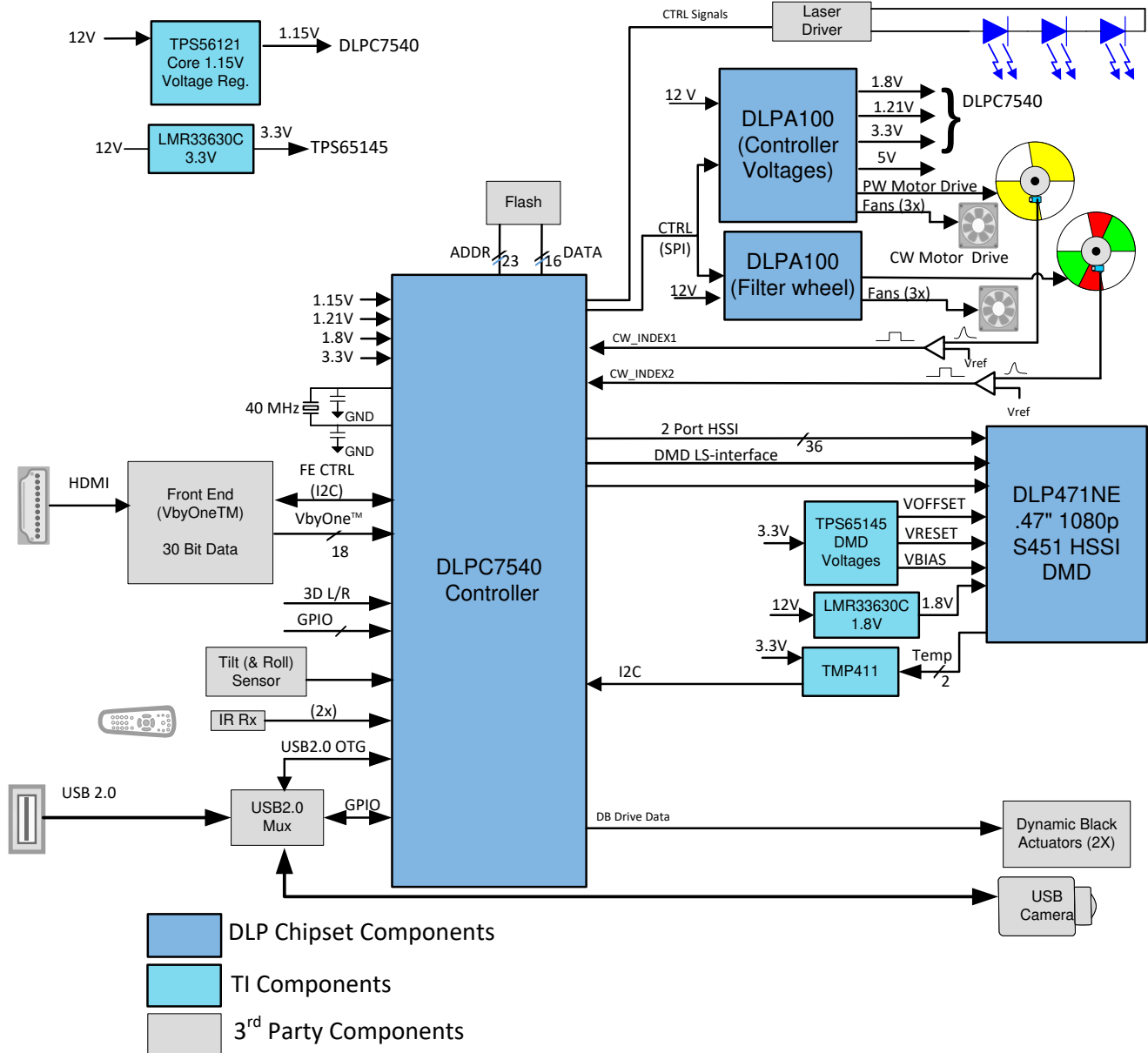


图 7-1. Typical Full HD Laser Phosphor Application Diagram

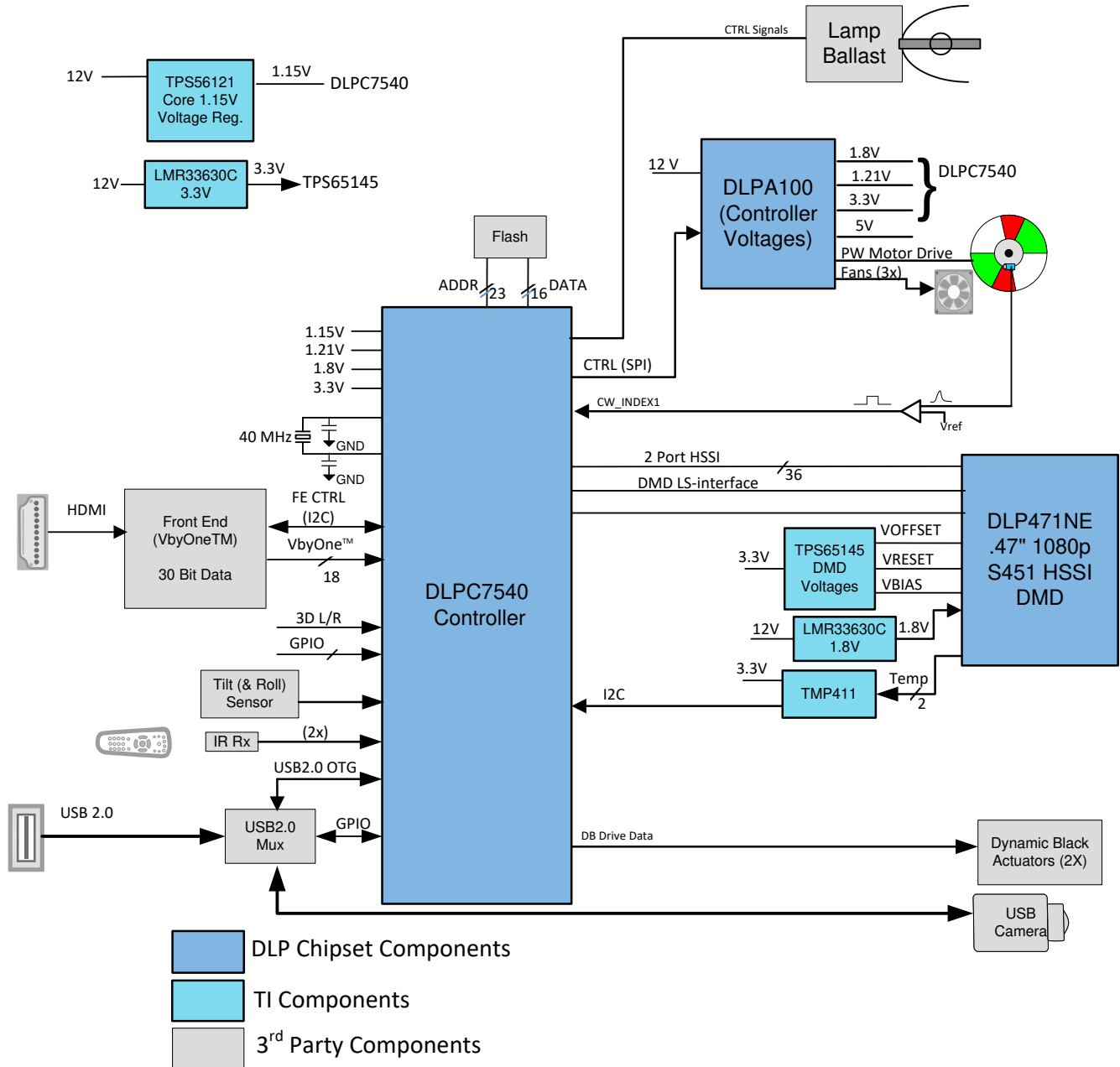


图 7-2. Typical Full HD Lamp Application Diagram

7.2.1 Design Requirements

Other core components of the display system include an illumination source, an optical engine for the illumination and projection optics, other electrical and mechanical components, and software. The type of illumination used and desired brightness have a major effect on the overall system design and size.

The display system uses the DLP471NE as the core imaging device and contains a 0.47-inch array of micromirrors. The **DLPC7540** controller is the digital interface between the DMD and the rest of the system, taking digital input from the front-end receiver and driving the DMD over a high-speed interface. The **DLPA100** PMIC serves as a voltage regulator for the controller, and color filter wheel and phosphor wheel motor control. The **TPS65145** provides the DMD reset, offset, and bias voltages. The **LMR33630C** provides the 1.8V power to the DLP471NE.

7.2.2 Detailed Design Procedure

For a complete DLP system, an optical module or light engine is required that contains the DLP471NE DMD, associated illumination sources, optical elements, and necessary mechanical components.

To ensure reliable operation, the DMD must always be used with [DLPC7540](#) display controller and the [TPS65145](#) PMIC and [DLPA100](#). Refer to [PCB Design Requirements for TI DLP TRP Digital Micromirror Devices](#) for the DMD board design and manufacturing handling of the DMD sub-assemblies.

7.2.3 Application Curve

In a typical projector application, the luminous flux on the screen from the DMD depends on the optical design of the projector. The efficiency and total power of the illumination optical system and the projection optical system determine the overall light output of the projector. The DMD is inherently a linear spatial light modulator, so its efficiency just scales the light output. [图 7-3](#) describes the relationship of laser input optical power to light output for a laser-phosphor illumination system, where the phosphor is not at its thermal quenching limit.

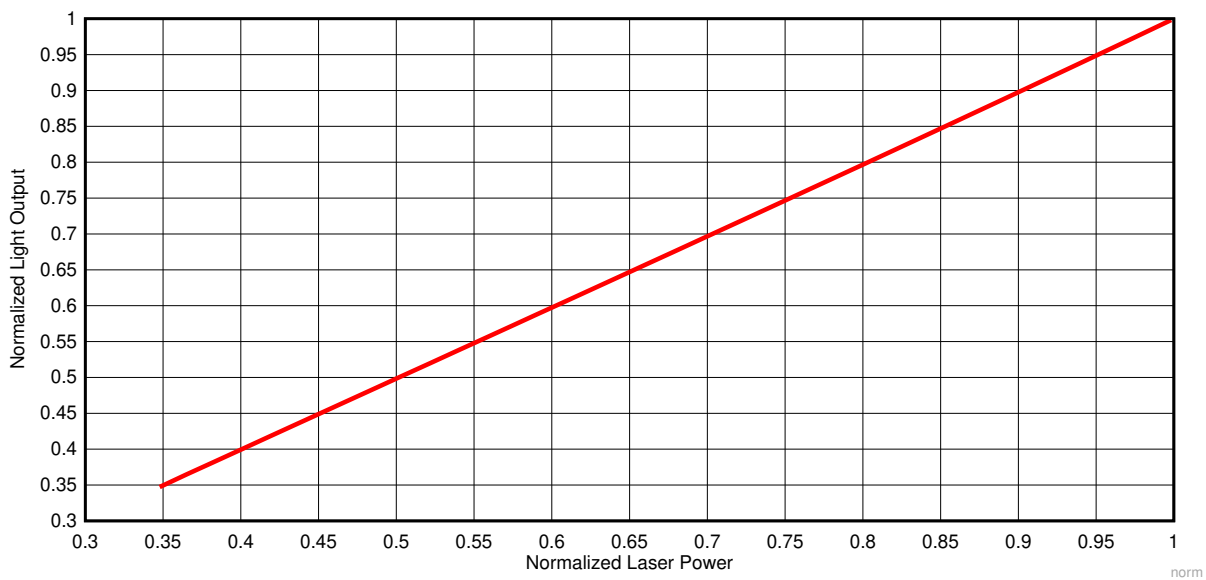
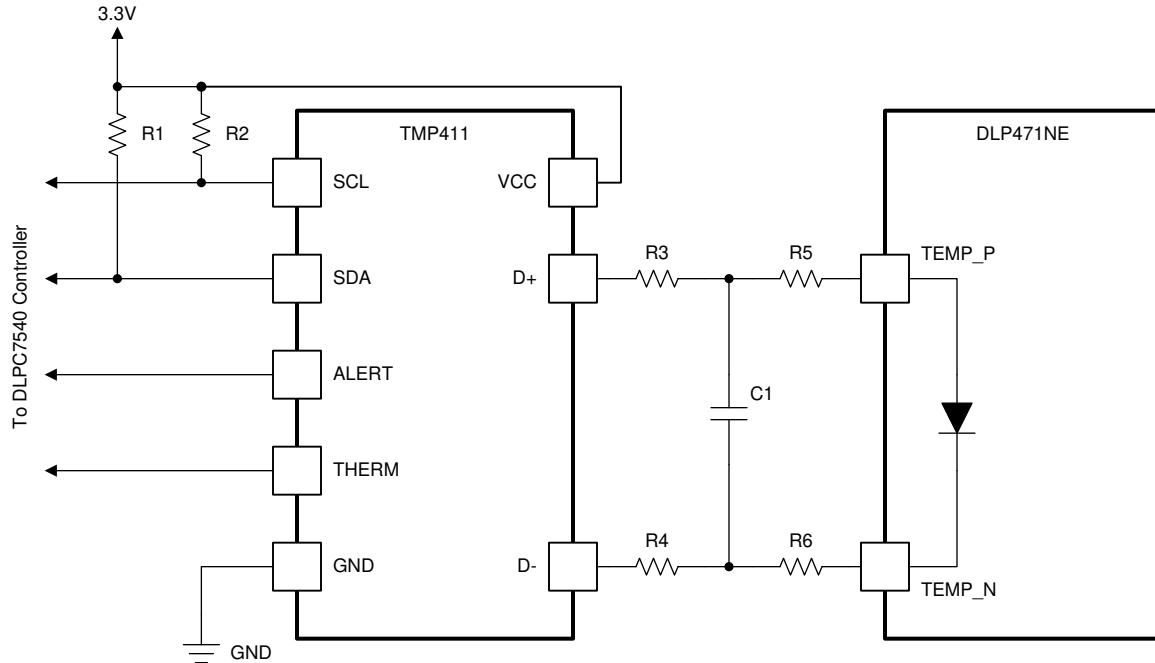


图 7-3. Normalized Light Output vs Normalized Laser Power for Laser Phosphor Illumination

7.3 Temperature Sensor Diode

The DMD features a built-in thermal diode that measures the temperature at one corner of the die outside the micromirror array. The thermal diode can be interfaced with the TMP411 temperature sensor as shown in [图 7-4](#). The software application contains functions to configure the [TMP411](#) to read the DLP471NE DMD temperature sensor diode. This data can be leveraged by the customer to incorporate additional functionality in the overall system design such as adjusting illumination, fan speeds, and so on. All communication between the [TMP411](#) and the [DLPC7540](#) controller happens over the I²C interface. The [TMP411](#) connects to the DMD via pins outlined in [表 4-1](#).

If the temp sensor is not used, TEMP_N and TEMP_P pins should be left unconnected (NC).



- A. Details are omitted for clarity.
- B. See the [TMP411](#) data sheet for the system board layout recommendation.
- C. See the [TMP411](#) data sheet and the TI reference design for suggested component values for R1, R2, R3, R4, and C1.
- D. $R5 = 0\ \Omega$. $R6 = 0\ \Omega$. Place $0\ \Omega$ resistors close to the DMD package pins.

图 7-4. TMP411 Sample Schematic

8 Power Supply Recommendations

The following power supplies are all required to operate the DMD:

- V_{SS}
- V_{BIAS}
- V_{DD}
- V_{OFFSET}
- V_{RESET}

DMD power-up and power-down sequencing are strictly controlled by the DLP display controller.

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For reliable operation of the DMD, the following power supply sequencing requirements must be followed. Failure to adhere to any of the prescribed power-up and power-down requirements may affect device reliability. See the DMD power supply sequencing requirements in 图 8-1.

V_{BIAS} , V_{DD} , V_{OFFSET} , and V_{RESET} power supplies must be coordinated during power-up and power-down operations. Failure to meet any of the below requirements will result in a significant reduction in the DMD reliability and lifetime. Common ground V_{SS} must also be connected.

表 8-1. Power Supply Sequence Requirements

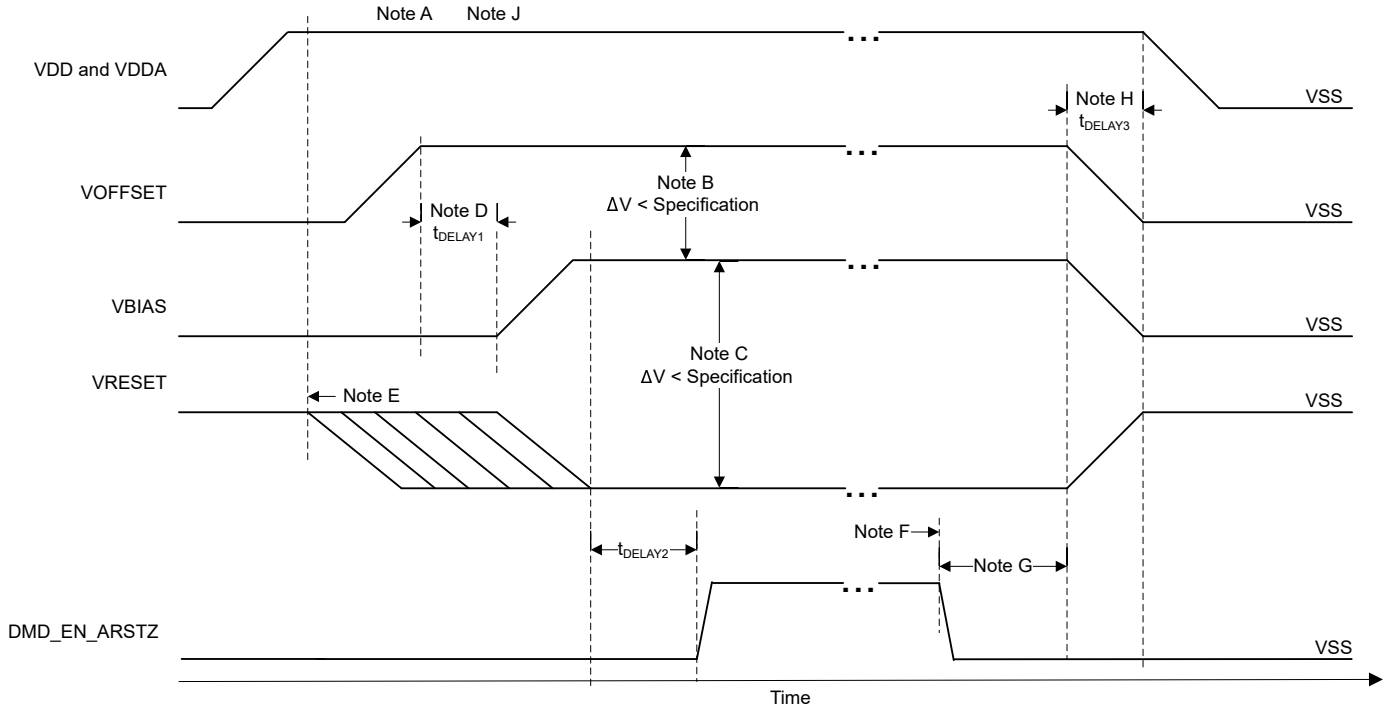
SYMBOL	PARAMETER	DESCRIPTION	MIN	TYP	MAX	UNIT
t_{DELAY1}	Delay requirement	from V_{OFFSET} power up to V_{BIAS} power up	1	2		ms
t_{DELAY2}	Delay requirement	from V_{BIAS} and V_{RESET} powered on and stable to DMD_EN_ARSTZ going high	20			μ s
t_{DELAY3}	Delay requirement	from V_{OFFSET} , V_{BIAS} , and V_{RESET} power down to when VDD and VDDA can power down	50			μ s

8.1 DMD Power Supply Power-Up Procedure

- During power-up, V_{DD} must always start and settle before V_{OFFSET} plus t_{DELAY1} specified in the figure *DMD Power Supply Requirements*, V_{BIAS} , and V_{RESET} voltages are applied to the DMD.
- During power-up, it is a strict requirement that the voltage difference between V_{BIAS} and V_{OFFSET} must be within the specified limit shown in the *Recommended Operating Conditions*.
- During power-up, there is no requirement for the relative timing of V_{RESET} with respect to V_{BIAS} .
- Power supply slew rates during power-up are flexible, provided that the transient voltage levels follow the requirements specified in the *Absolute Maximum Ratings*, the *Recommended Operating Conditions*, and the figure *DMD Power Supply Requirements*.
- During power-up, LVCMOS input pins must not be driven high until after V_{DD} has settled at the operating voltage listed in the *Recommended Operating Conditions*.

8.2 DMD Power Supply Power-Down Procedure

- During power-down, V_{DD} must be supplied until after V_{BIAS} , V_{RESET} , and V_{OFFSET} are discharged to within the specified limit of ground. See the figure *DMD Power Supply Requirements*.
- During power-down, it is a strict requirement that the voltage difference between V_{BIAS} and V_{OFFSET} must be within the specified limit shown in the *Recommended Operating Conditions*.
- During power-down, there is no requirement for the relative timing of V_{RESET} with respect to V_{BIAS} .
- Power supply slew rates during power-down are flexible, provided that the transient voltage levels follow the requirements specified in the *Absolute Maximum Ratings*, the *Recommended Operating Conditions*, and in the figure *DMD Power Supply Requirements*.
- During power-down, LVCMOS input pins must be less than specified in *Recommended Operating Conditions*.



- A. See [节 4](#) for the *Pin Functions Table*.
- B. To prevent excess current, the supply voltage difference $|V_{BIAS} - V_{OFFSET}|$ must be less than the specified limit in the *Recommended Operating Conditions*.
- C. To prevent excess current, the supply difference $|V_{BIAS} - V_{RESET}|$ must be less than the specified limit in the *Recommended Operating Conditions*.
- D. V_{BIAS} must power up after V_{OFFSET} has powered up, per the Delay1 specification in [表 8-1](#).
- E. V_{RESET} , V_{OFFSET} , and V_{BIAS} ramps must start after VDD and VDPA are powered up and stable.
- F. After the DMD micromirror park sequence is complete, the DLP controller software initiates a hardware power-down that activates DMD_EN_ARSTZ and disables V_{BIAS} , V_{RESET} , and V_{OFFSET} .
- G. Under power-loss conditions where emergency DMD micromirror park procedures are being enacted by the DLP controller hardware, DMD_EN_ARSTZ goes low.
- H. V_{DD} must remain high until after V_{OFFSET} , V_{BIAS} , and V_{RESET} go low, per Delay2 specification in [表 8-1](#).
- I. To prevent excess current, the supply voltage delta $|V_{DDA} - V_{DD}|$ must be less than the specified limit in *Recommended Operating Conditions*.
- J. Not to scale. Details are omitted for clarity.

图 8-1. DMD Power Supply Requirements

9 Layout

9.1 Layout Guidelines

The DLP471NE DMD is part of a chipset that is controlled by the [DLPC7540](#) display controller in conjunction with the [TPS65145](#) PMIC and the [DLPA100](#) power and motor controller. These guidelines are targeted at designing a PCB board with the DLP471NE DMD. The DMD board is a high-speed multi-layer PCB, with primarily high-speed digital logic including double data rate 3.2Gbps and 250Mbps differential data buses run to the DMD. TI recommends that full or mini power planes are used for V_{OFFSET} , V_{RESET} , and V_{BIAS} . Solid planes are required for ground (V_{SS}). The target impedance for the PCB is $50\ \Omega \pm 10\%$ with exceptions listed in [表 9-1](#). TI recommends a 10 layer stack-up as described in [表 9-2](#). TI recommends manufacturing the PCB with a high quality FR-4 material.

9.2 Impedance Requirements

TI recommends a target impedance for the PCB of $50\ \Omega \pm 10\%$ for all signals. [表 9-1](#) lists the exceptions.

表 9-1. Special Impedance Requirements

SIGNAL TYPE	SIGNAL NAME	IMPEDANCE (Ω)
DMD High Speed Data Signals	DMD_HSSI0_N_(0...7), DMD_HSSI0_P_(0...7), DMD_HSSI1_N_(0...7), DMD_HSSI1_P_(0...7), DMD_HSSI0_CLK_N, DMD_HSSI0_CLK_P, DMD_HSSI1_CLK_N, DMD_HSSI1_CLK_P	100 Ω differential (50 Ω single ended)
DMD Low Speed Interface Signals	DMD_LS0_WDATA_N, DMD_LS0_WDATA_P, DMD_LS0_CLK_N, DMD_LS0_CLK_P	100 Ω differential (50 Ω single ended)

9.3 Layers

[表 9-2](#) shows the layer stack-up and copper weight for each layer.

表 9-2. Layer Stack-Up

LAYER NO.	LAYER NAME	COPPER WT. (oz.)	COMMENTS
1	Side A - DMD, primary components, power mini-planes	0.5oz (before plating)	DMD and escapes. Two data input connectors. Top components including power generation and two data input connectors. Low frequency signals routing. Should have a copper fill (GND) plated up to 1oz
2	Ground	0.5	Solid ground plane (net GND) reference for signal layers #1, 3
3	Signal (high frequency)	0.5	High speed signal layer. High speed differential data buses from input connector to DMD
4	Ground	0.5	Solid ground plane (net GND) reference for signal layers #3, #5
5	Power	0.5	Primary split power planes for 1.8V, 3.3V, 10V, - 14V, 18V
6	Power	0.5	Primary split power planes for 1.8V, 3.3V, 10V, - 14V, 18V.
7	Ground	0.5	Solid ground plane (net GND) reference for signal layer #8
8	Signal (high frequency)	0.5	High Speed Signal layer. High speed differential data buses from input connector to DMD
9	Ground	0.5	Solid ground plane (net GND) reference for signal layers #8, 10
10	Side B - secondary components, power mini-planes	0.5oz (before plating)	Discrete components if necessary. Low frequency signals routing. Should have copper fill plated up to 1oz

9.4 Trace Width, Spacing

Unless otherwise specified, TI recommends that all signals follow the 0.005" /0.015" (trace-width/spacing) design rule. Use an analysis of impedance and stack-up requirements to determine and calculate actual trace widths.

Maximized the width of all voltage signals as space permits. Follow the width and spacing requirements listed in [表 9-3](#).

表 9-3. Special Trace Widths, Spacing Requirements

SIGNAL NAME	MINIMUM TRACE WIDTH (MIL)	MINIMUM TRACE SPACING (MIL)	LAYOUT REQUIREMENT
GND	MAXIMIZE	5	Maximize trace width to connecting pin as a minimum
V _{DD}	40	15	Create mini planes on layers 1 and 10 as needed. Connect to devices on layers 1 and 10 as necessary with multiple vias.
V _{DDA}	40	15	Create mini planes on layers 1 and 10 as needed. Connect to devices on layers 1 and 10 as necessary with multiple vias.
V _{OFFSET}	40	15	Create mini-planes on layers 1 and 10 as needed. Connect to devices on layers 1 and 10 as necessary.
V _{RESET}	40	15	Create mini-planes on layers 1 and 10 as needed. Connect to devices on layers 1 and 10 as necessary.
V _{BIAS}	40	15	Create mini-planes on layers 1 and 10 as needed. Connect to devices on layers 1 and 10 as necessary.

9.5 Power

TI strongly discourages signal routing on power planes or on planes adjacent to power planes. If signals must be routed on layers adjacent to power planes, they must not cross splits in power planes to prevent EMI and preserve signal integrity.

Connect all internal digital ground (GND) planes in as many places as possible. Connect all internal ground planes with a minimum distance between connections of 0.5" . Extra vias may not required if there are sufficient ground vias due to normal ground connections of devices.

Connect power and ground pins of each component to the power and ground planes with at least one via for each pin. Minimize trace lengths for component power and ground pins. (ideally, less than 0.100").

Ground plane slots are strongly discouraged.

9.6 Trace Length Matching Recommendations

表 9-4 和 表 9-5 描述推荐的信号走线长度匹配要求。遵循这些指南以避免在 PCB 上走很长的线。

- Match the trace lengths so that longer signals route in a serpentine pattern.
- Minimize the number of turns.
- Ensure that the turn angles no sharper than 45 degrees.

图 9-1 显示了 HSSI 信号对走线的示例。

表 9-4 中列出的信号指定为可在高达 3.2Gbps 的数据速率下操作。对于这些信号，请尽量减少层更改。尽量减少过孔的数量。避免锐角转弯和层切换，同时尽量减少长度。当层更改是必要的，请在信号过孔周围放置 GND 过孔，以提供信号返回路径。一对差分信号之间的距离必须至少是信号对内部距离的两倍。

表 9-4. HSSI High-Speed DMD Data Signals

SIGNAL NAME	REFERENCE SIGNAL	ROUTING SPECIFICATION	UNIT
DMD_HSSI0_N(0...7), DMD_HSSI0_P(0...7)	DMD_HSSI0_CLK_N, DMD_HSSI0_CLK_P	±0.25	inch
DMD_HSSI1_N(0...7), DMD_HSSI1_P(0...7)	DMD_HSSI0_CLK_N, DMD_HSSI0_CLK_P	±0.25	inch
DMD_HSSI0_CLK_P	DMD_HSSI1_CLK_P	±0.05	inch
Intra-pair P	Intra-pair N	±0.01	inch

表 9-5. Other Timing Critical Signals

SIGNAL NAME	CONSTRAINTS	ROUTING LAYERS
LS_CLK_P, LS_CLK_N LS_WDATA_P, LS_WDATA_N LS_RDATA_A	Intra-pair (P to N) Matched to 0.01 inches Signal-to-signal Matched to +/- 0.25 inches	Layers 3, 8

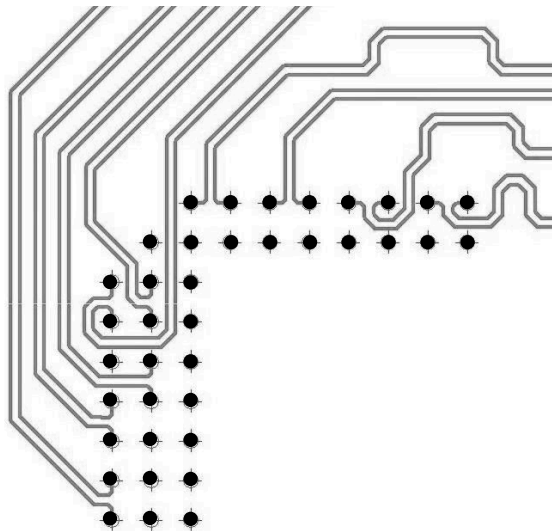


图 9-1. Example HSSI PCB Routing

10 Device and Documentation Support

10.1 第三方产品免责声明

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10.2 Device Support

10.2.1 Device Nomenclature

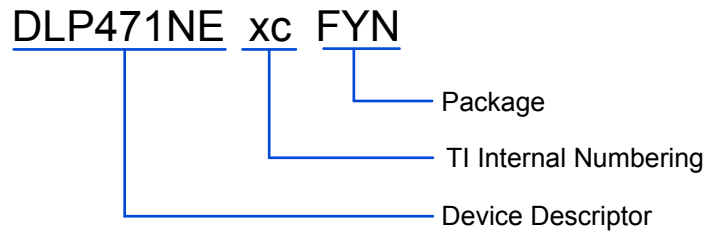


图 10-1. Part Number Description

10.2.2 Device Markings

The device marking includes both human-readable information and a 2-dimensional matrix code. The human-readable information is described in 图 10-2. The 2-dimensional matrix code is an alpha-numeric string that contains the DMD part number, Part 1 and Part 2 of the serial number.

Example:

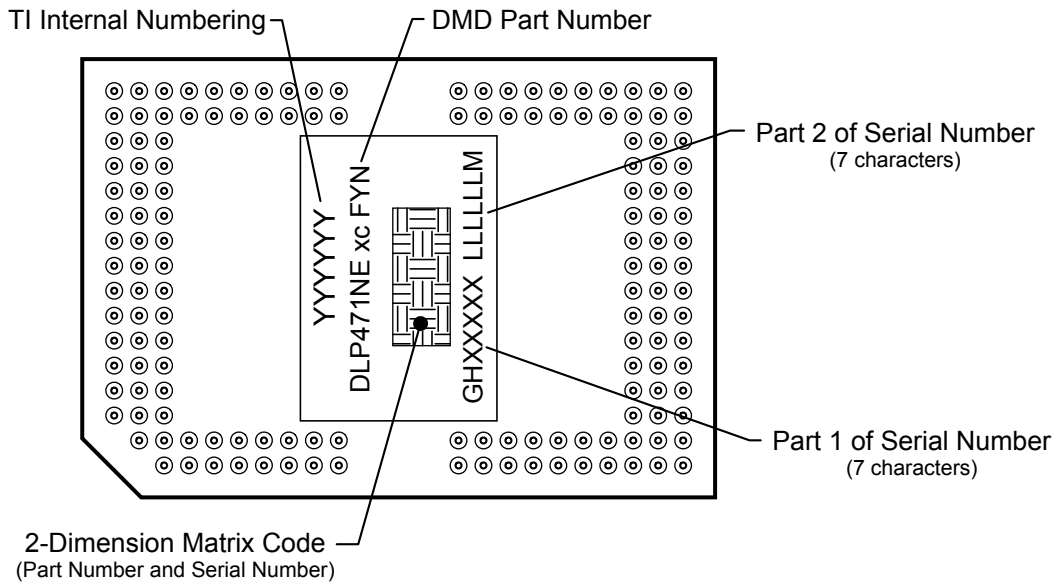


图 10-2. DMD Marking Locations

10.3 Documentation Support

10.3.1 Related Documentation

The following documents contain additional information related to the chipset components used with the DMD.

- [DLPC7540 Display Controller Data Sheet](#)
- [TPS65145 Data Sheet](#)
- [DLPA100 Power and Motor Driver Data Sheet](#)

10.4 Receiving Notification of Documentation Updates

To receive notification of documentation updates, navigate to the device product folder on ti.com. In the upper right corner, click on *Alert me* to register and receive a weekly digest of any product information that has changed. For change details, review the revision history included in any revised document.

10.5 支持资源

TI E2E™ 中文支持论坛是工程师的重要参考资料，可直接从专家处获得快速、经过验证的解答和设计帮助。搜索现有解答或提出自己的问题，获得所需的快速设计帮助。

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10.7 静电放电警告



静电放电 (ESD) 会损坏这个集成电路。德州仪器 (TI) 建议通过适当的预防措施处理所有集成电路。如果不遵守正确的处理和安装程序，可能会损坏集成电路。

ESD 的损坏小至导致微小的性能降级，大至整个器件故障。精密的集成电路可能更容易受到损坏，这是因为非常细微的参数更改都可能会导致器件与其发布的规格不相符。

10.8 术语表

TI 术语表 本术语表列出并解释了术语、首字母缩略词和定义。

11 Revision History

注：以前版本的页码可能与当前版本的页码不同

Changes from Revision B (May 2022) to Revision C (January 2025)	Page
• 添加了 DLP 产品第三方搜索工具链接，以及 TI DLP 显示技术入门链接.....	1
• Added sections SOLID STATE ILLUMINATION and LAMP ILLUMINATION to Recommended Operating Conditions table.....	7
• Updated Micromirror Array Optical Characteristics Table.....	18
• Updated Micromirror Array Temperature Calculation.....	23

Changes from Revision A (September 2021) to Revision B (May 2022)	Page
• 根据最新的德州仪器 (TI) 和行业数据表标准对本文档进行了更新.....	1
• Updated the definition of $t_{\text{DELAY}2}$ and fixed a typo in $t_{\text{DELAY}3}$ units in 表 8-1	35
• Updated 图 8-1	35

12 Mechanical, Packaging, and Orderable Information

The following pages include mechanical, packaging, and orderable information. This information is the most current data available for the designated devices. This data is subject to change without notice and revision of this document. For browser-based versions of this data sheet, refer to the left-hand navigation.

12.1 Package Option Addendum

12.1.1 Packaging Information

Orderable Device	Status ⁽¹⁾	Package Type	Package Drawing	Pins	Package Qty	Eco Plan ⁽²⁾	Lead/Ball Finish ⁽⁴⁾	MSL Peak Temp ⁽³⁾	Op Temp (°C)	Device Marking ⁽⁵⁾ ⁽⁶⁾
DLP471NEA0FYN	ACTIVE	CPGA	FYN	149	33	RoHS & Green	Call TI	Call TI		see <i>Device Marking</i> section

- (1) The marketing status values are defined as follows:
ACTIVE: Product device recommended for new designs.
LIFEBUY: TI has announced that the device will be discontinued, and a lifetime-buy period is in effect.
NRND: Not recommended for new designs. Device is in production to support existing customers, but TI does not recommend using this part in a new design.
PRE_PROD Unannounced device, not in production, not available for mass market, nor on the web, samples not available.
PREVIEW: Device has been announced but is not in production. Samples may or may not be available.
OBSOLETE: TI has discontinued the production of the device.
- (2) Eco Plan - The planned eco-friendly classification: Pb-Free (RoHS), Pb-Free (RoHS Exempt), or Green (RoHS & no Sb/Br) - please check <http://www.ti.com/productcontent> for the latest availability information and additional product content details.
TBD: The Pb-Free/Green conversion plan has not been defined.
Pb-Free (RoHS): TI's terms "Lead-Free" or "Pb-Free" mean semiconductor products that are compatible with the current RoHS requirements for all 6 substances, including the requirement that lead not exceed 0.1% by weight in homogeneous materials. Where designed to be soldered at high temperatures, TI Pb-Free products are suitable for use in specified lead-free processes.
Pb-Free (RoHS Exempt): This component has a RoHS exemption for either 1) lead-based flip-chip solder bumps used between the die and package, or 2) lead-based die adhesive used between the die and leadframe. The component is otherwise considered Pb-Free (RoHS compatible) as defined above.
Green (RoHS & no Sb/Br): TI defines "Green" to mean Pb-Free (RoHS compatible), and free of Bromine (Br) and Antimony (Sb) based flame retardants (Br or Sb do not exceed 0.1% by weight in homogeneous material)
- (3) MSL, Peak Temp. -- The Moisture Sensitivity Level rating according to the JEDEC industry standard classifications, and peak solder temperature.
- (4) Lead/Ball Finish - Orderable Devices may have multiple material finish options. Finish options are separated by a vertical ruled line. Lead/Ball Finish values may wrap to two lines if the finish value exceeds the maximum column width.
- (5) There may be additional marking, which relates to the logo, the lot trace code information, or the environmental category on the device
- (6) Multiple Device markings will be inside parentheses. Only one Device Marking contained in parentheses and separated by a "~" will appear on a device. If a line is indented then it is a continuation of the previous line and the two combined represent the entire Device Marking for that device.
Important Information and Disclaimer: The information provided on this page represents TI's knowledge and belief as of the date that it is provided. TI bases its knowledge and belief on information provided by third parties, and makes no representation or warranty as to the accuracy of such information. Efforts are underway to better integrate information from third parties. TI has taken and continues to take reasonable steps to provide representative and accurate information but may not have conducted destructive testing or chemical analysis on incoming materials and chemicals. TI and TI suppliers consider certain information to be proprietary, and thus CAS numbers and other limited information may not be available for release.
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TRAY



Chamfer on Tray corner indicates Pin 1 orientation of packed units.

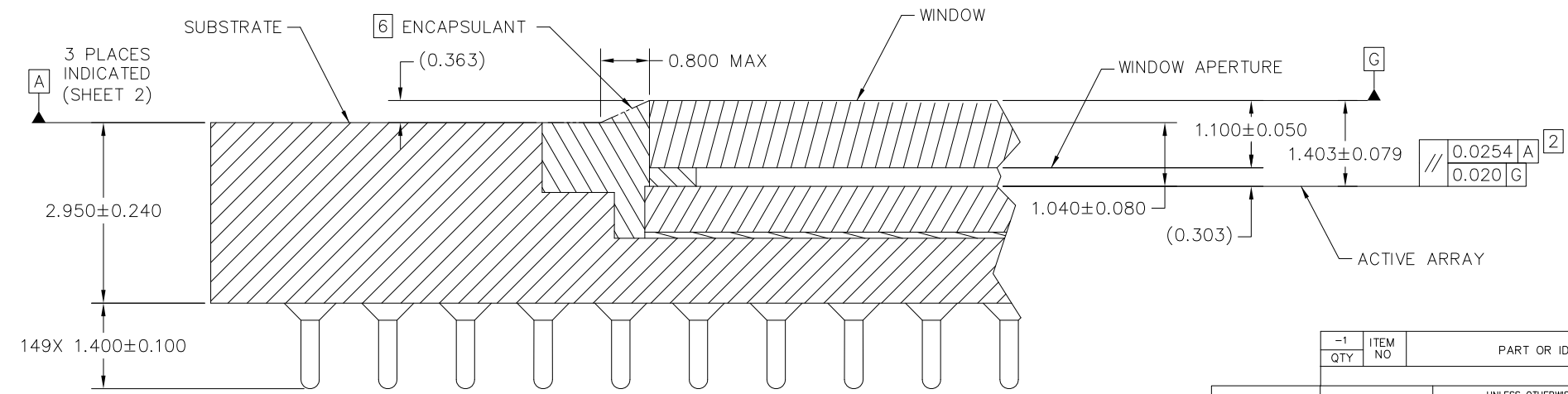
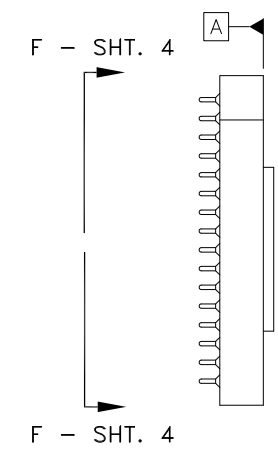
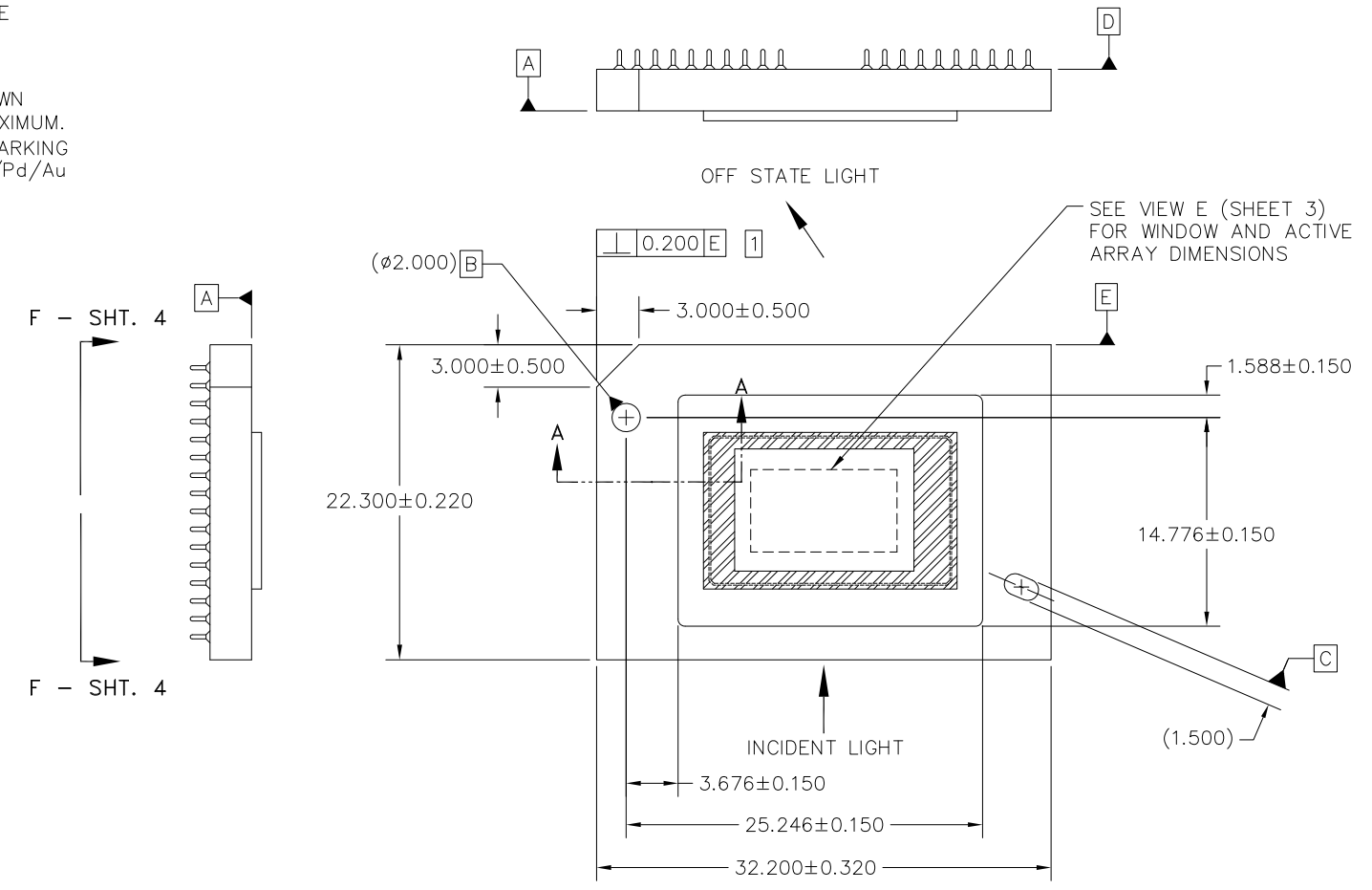
*All dimensions are nominal

Device	Package Name	Package Type	Pins	SPQ	Unit array matrix	Max temperature (°C)	L (mm)	W (mm)	K0 (µm)	P1 (mm)	CL (mm)	CW (mm)
DLP471NEA0FYN	FYN	CPGA	149	33	3 x 11	150	315	135.9	12190	27.5	20	27.45

REVISIONS			
REV	DESCRIPTION	DATE	APPROVED
A	ECO 2178180, INITIAL RELEASE	12/18/2018	F. ARMSTRONG
B	ECO 2179961, REMOVE '4k' DESIGNATION FROM TITLE	03/04/2019	F. ARMSTRONG
C	ECO 2180674, CORRECT THE ENCAP ON CERAMIC ALLOWABLE DIM FROM 3.226 MIN TO 2.300 MIN.	04/09/2019	F. ARMSTRONG
D	ECO 2187478, ADD APERTURE SLOTS PICTORIALLY	05/04/2020	P. CREERY

NOTES: UNLESS OTHERWISE SPECIFIED:

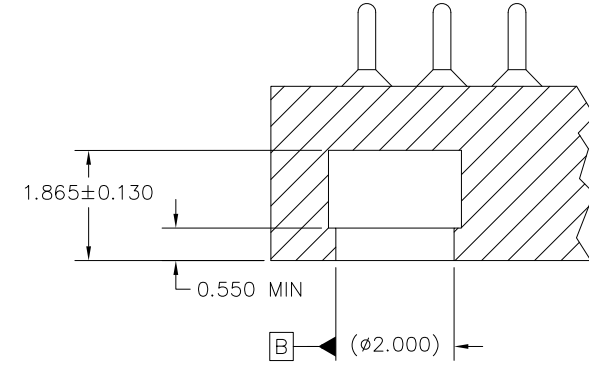
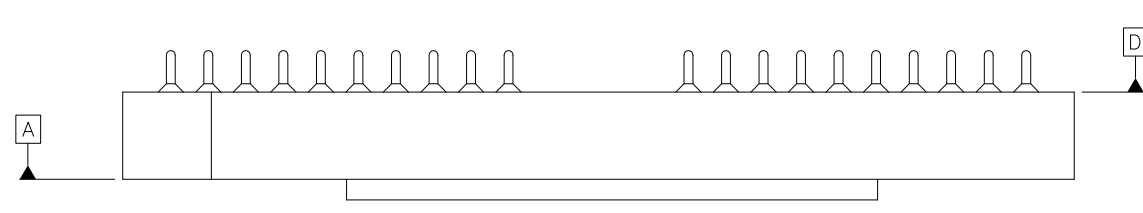
- 1 SUBSTRATE EDGE PERPENDICULARITY TOLERANCE APPLIES TO ENTIRE SURFACE
- 2 DIE PARALLELISM TOLERANCE APPLIES TO DMD ACTIVE ARRAY ONLY
- 3 ROTATION ANGLE OF DMD ACTIVE ARRAY IS A REFINEMENT OF THE LOCATION TOLERANCE AND HAS A MAXIMUM ALLOWED VALUE OF 0.8 DEGREES
- 4 SUBSTRATE SYMBOLIZATION PAD AND PLATING AT BOTTOM OF DATUMS B AND C HOLES TO BE ELECTRICALLY CONNECTED TO VSS PLANE WITHIN THE SUBSTRATE
- 5 BOUNDARY MIRRORS SURROUNDING THE DMD ACTIVE AREA
- 6 MAXIMUM ENCAPSULANT PROFILE SHOWN
- 7 ENCAPSULANT ALLOWED ON THE SURFACE OF THE CERAMIC IN THE AREA SHOWN IN VIEW B (SHEET 2). ENCAPSULANT SHALL NOT EXCEED 0.200 THICKNESS MAXIMUM.
- 8 SUBSTRATES PLATED WITH Ni/Au SHALL HAVE THE THREE-DIGIT NUMERICAL MARKING IN THE AREA ABOVE THE SYMBOLIZATION PAD. SUBSTRATES PLATED WITH Ni/Pd/Au SHALL HAVE THE MARKING IN THE AREA BELOW THE SYMBOLIZATION PAD.



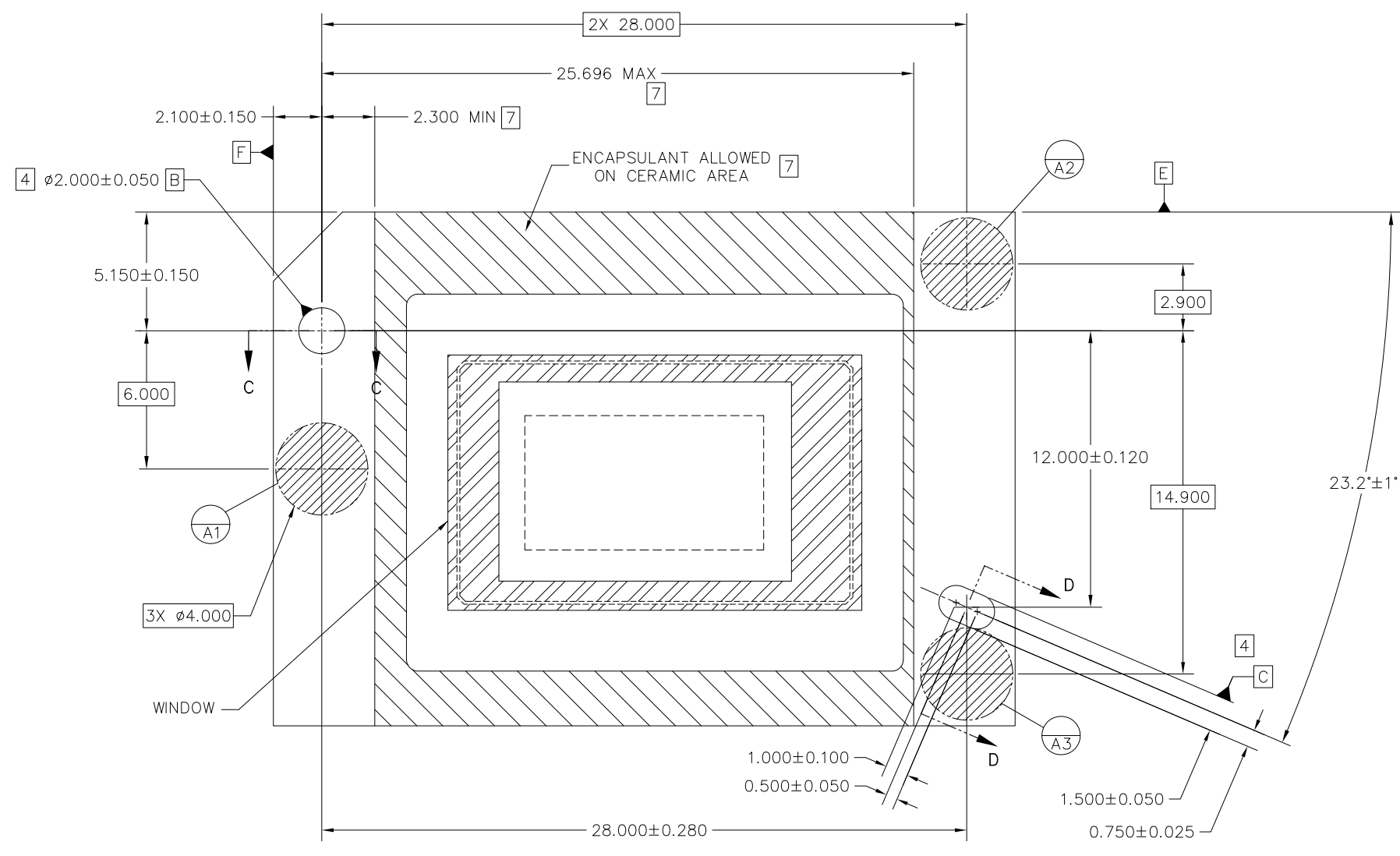
SECTION A-A
SCALE 20/1

-1 QTY	ITEM NO	PART OR IDENTIFYING NUMBER	NOMENCLATURE OR DESCRIPTION	NOTES
PARTS LIST				
	DWN	F. ARMSTRONG	DATE 12/18/18	<p style="text-align: center;">TEXAS INSTRUMENTS Dallas, Texas</p> <p style="text-align: center;">ICD, MECHANICAL, DMD .47" MTRP HSSI SERIES 451 (FYN PACKAGE)</p> <p style="text-align: right;">DRAWING NO 2516515 REV D</p>
	ENGR	F. ARMSTRONG	DATE 12/18/18	
	QA	K. DICKERSON	DATE 12/21/18	
	COE	M. DORAK	DATE 12/21/18	
		NONE	0314DA	
		NEXT ASSY	USED ON	
		APPLICATION		

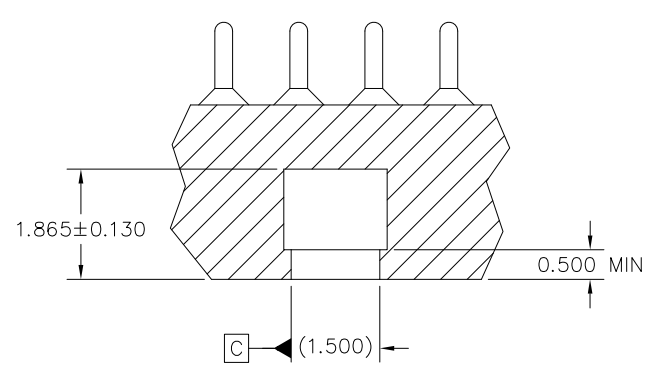




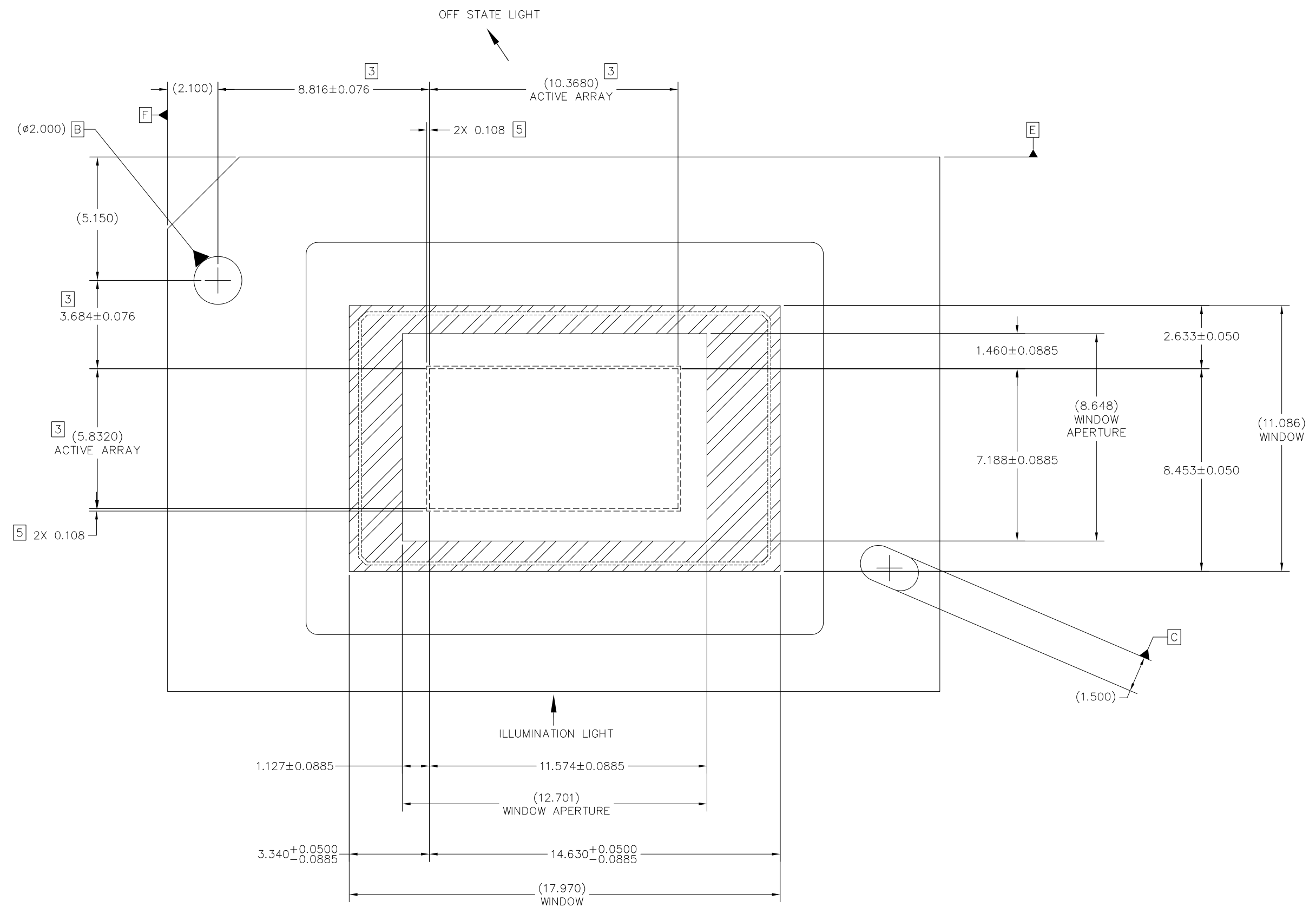
SECTION C-C
DATUM B
SCALE 16/1



VIEW B
DATUMS AND ENCAPSULANT ALLOWABLE AREA
SCALE 8/1

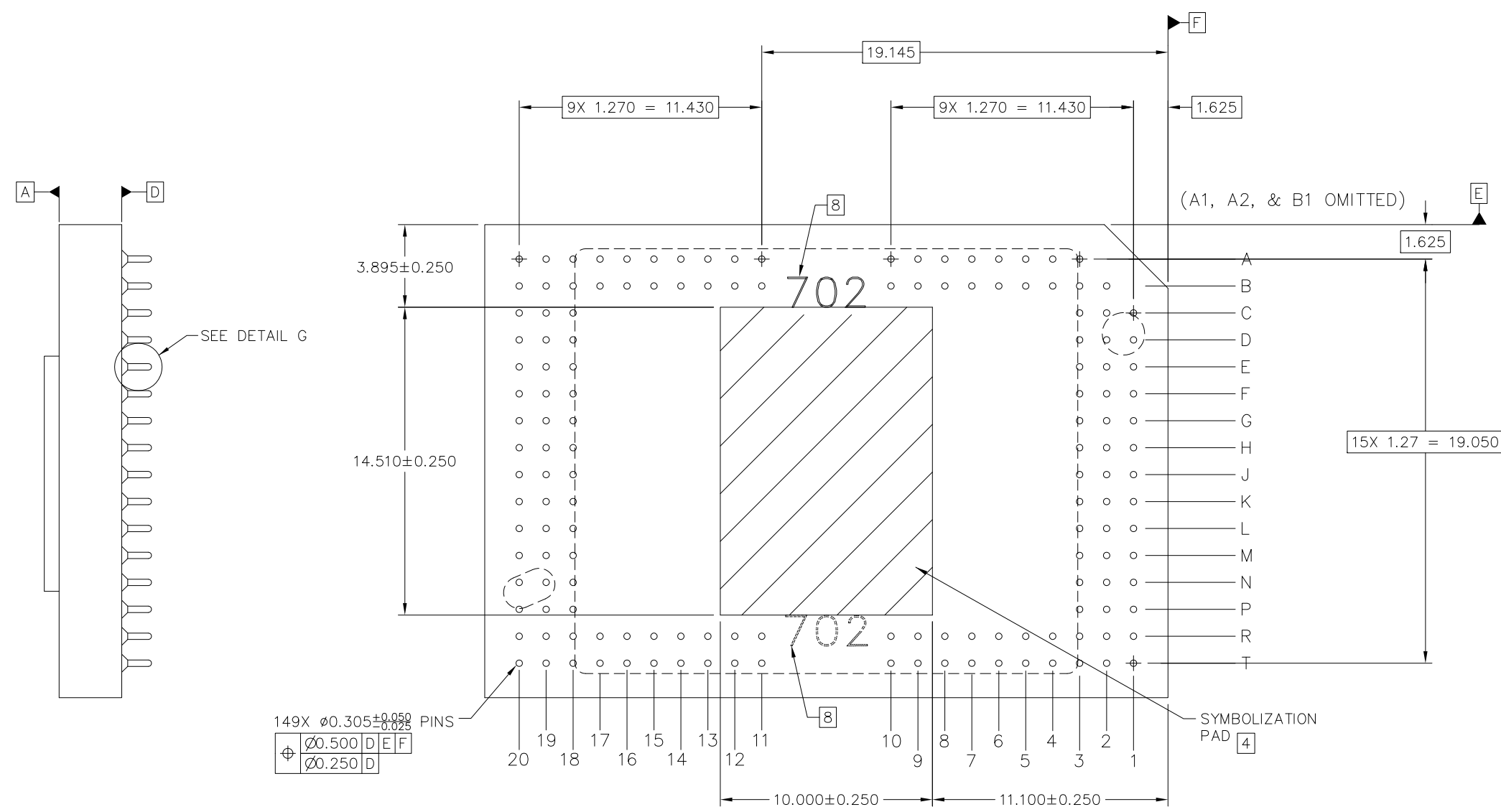


SECTION D-D
DATUM C
SCALE 16/1

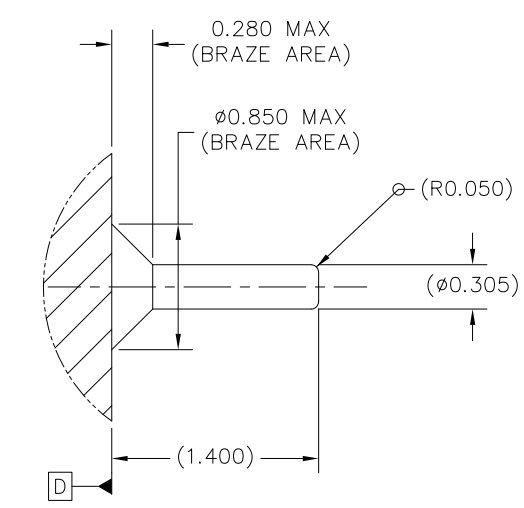


VIEW E (SHEET 1)
 DMD WINDOW AND ACTIVE ARRAY
 SCALE 12/1

 TEXAS INSTRUMENTS <i>Dallas, Texas</i>	DWN	DATE	SIZE	DRAWING NO	REV
	ISSUE DATE	SCALE	4/1	2516515	D
				SHEET	3



VIEW F-F (SHEET 1)
PINS AND SYMBOLIZATION PAD
SCALE 8/1



DETAIL G (149 PLACES)
PIN & BRAZE DIMENSIONS
SCALE 40/1

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